



ROYAL INSTITUTE
OF TECHNOLOGY

Micromachining

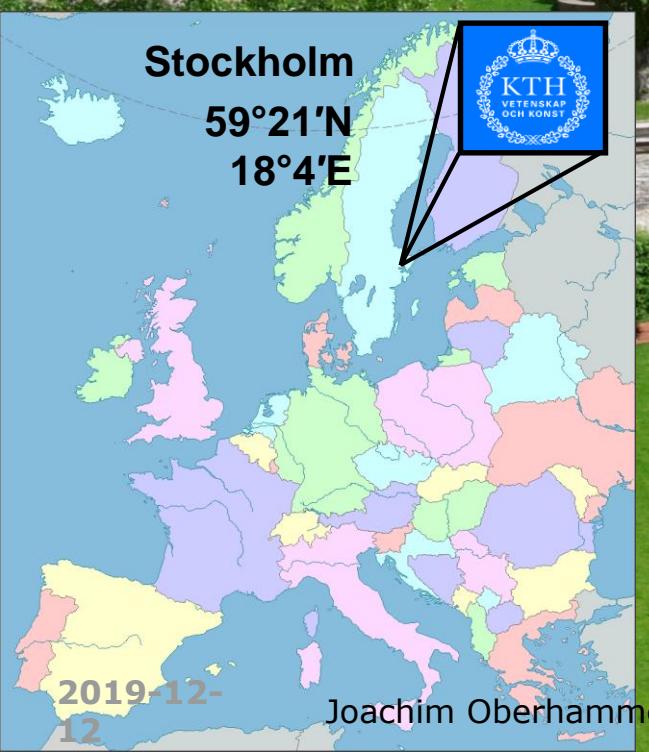
enabling new solutions at millimeter and submillimeter frequencies

Joachim Oberhammer
Prof., Microwave and THz Microsystems
Assoc. Editor, IEEE Trans. THz Science and Technology

KTH Royal Institute of Technology – School of Electrical Engineering
100 44 Stockholm, Sweden *joachim.oberhammer@ee.kth.se*



ROYAL INSTITUTE
OF TECHNOLOGY



Microwave/THz MEMS@KTH

(School of EE and CS)

Group size:

- 1 professor
- 3 senior researchers
- 10 PhD students

Average external project funding:

- >EUR 1 million/year

KTH micro&THz resources:

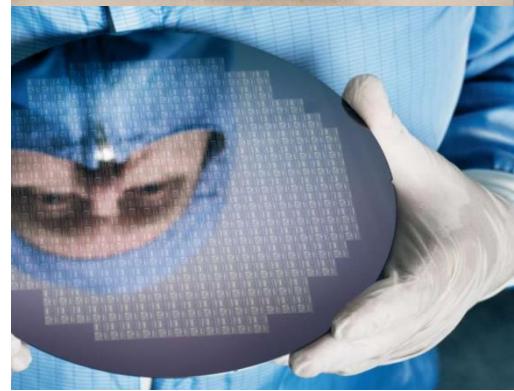


ELECTRUM LAB
KTH & ACREO IN COLLABORATION



- 1300m² class 100 clean-room for MEMS, photonics, III-V, SiC
- MW characterization (VNA, antennas) to 500 GHz

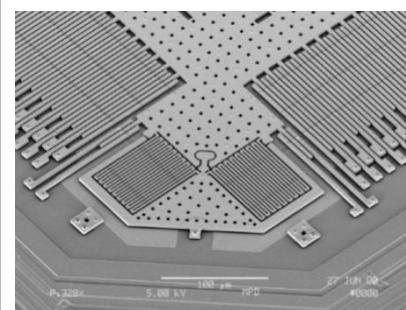




Semiconductor clean-room manufacturing:

- miniaturization
- very high volume
- very low cost

**Revolutionized
information age**

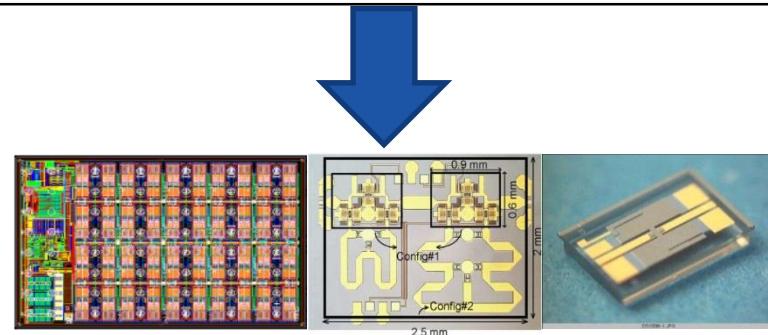


inertial sensors,
microphones, ...
billions devices/year,
<1 EUR/dev

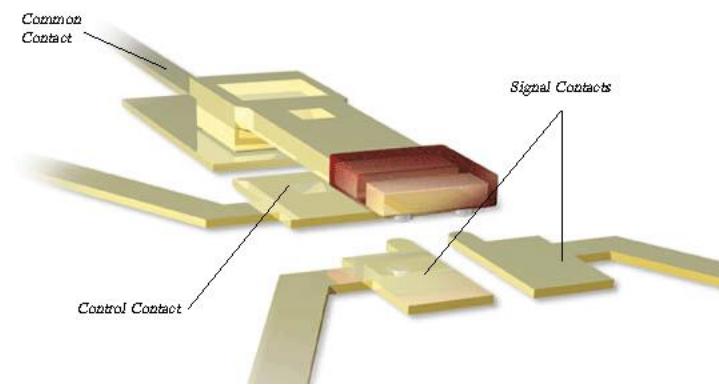
**Revolutionized
sensors and
user interfaces**

Micro-mechanics MEMS

Micro-ElectroMechanical Systems



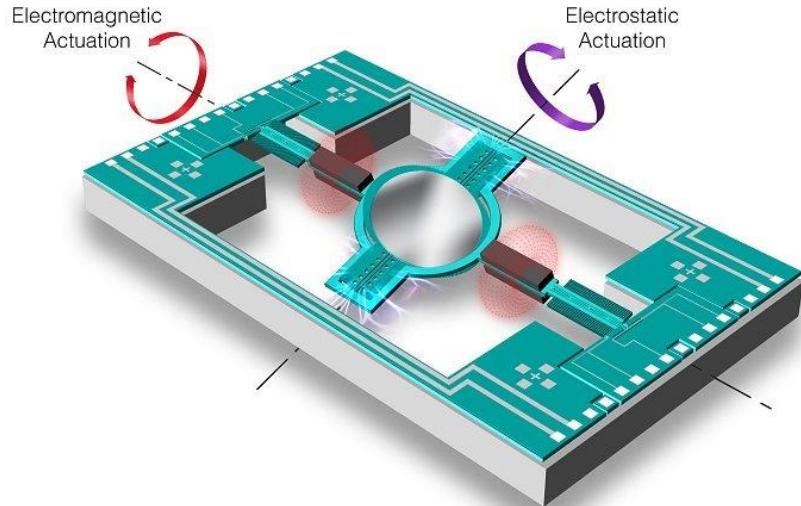
RF (radio-frequency) MEMS:
mobile phone antenna tuners,...



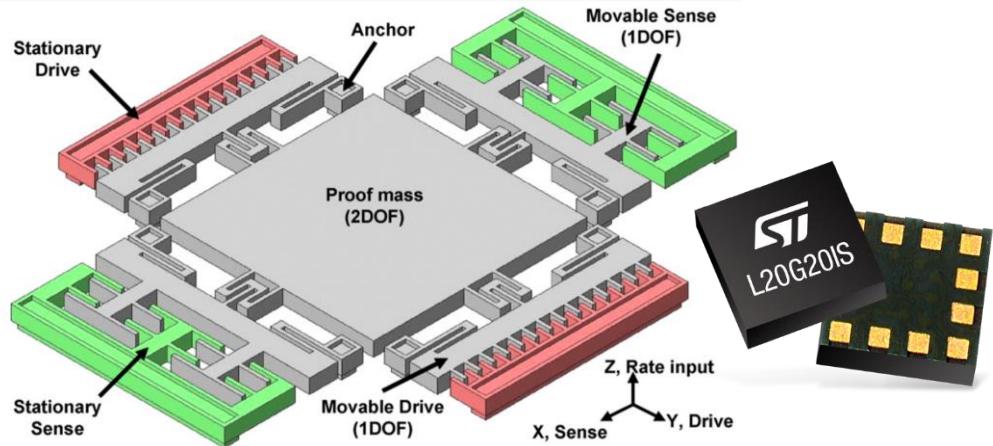
Typical performance:

- insertion loss < 0.5 dB @ 38 GHz
- isolation: 23 dB @ 10 GHz, 18 dB @ 36 GHz
- linearity IIP3 > 65 dBm

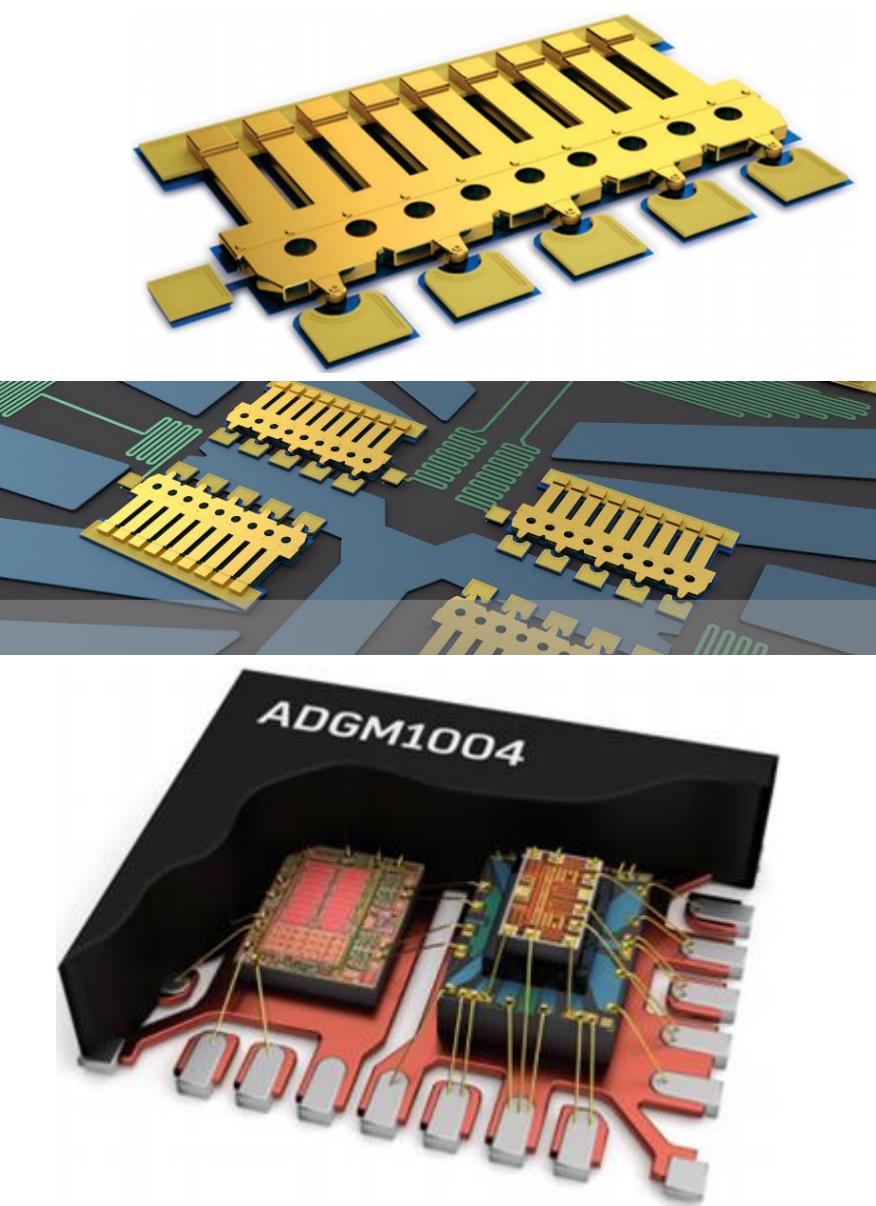
MEMS examples ...



Moveable micromirror for LIDAR



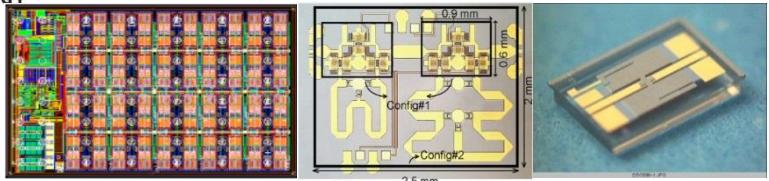
MEMS gyroscope



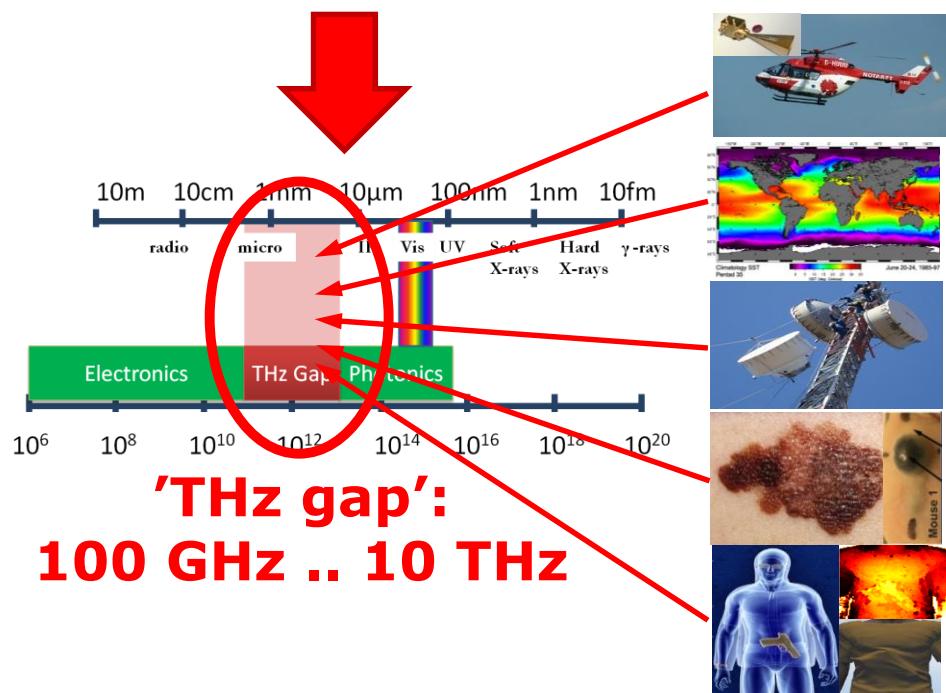
Analog devices SP4T MEMS switch:
13 GHz BW, IL 0.45 dB (2.5 GHz),
ISO 30 dB (1GHz)
3.4 billion cycles (hot switched, 10 dBm)

From RF MEMS to THz MEMS ...

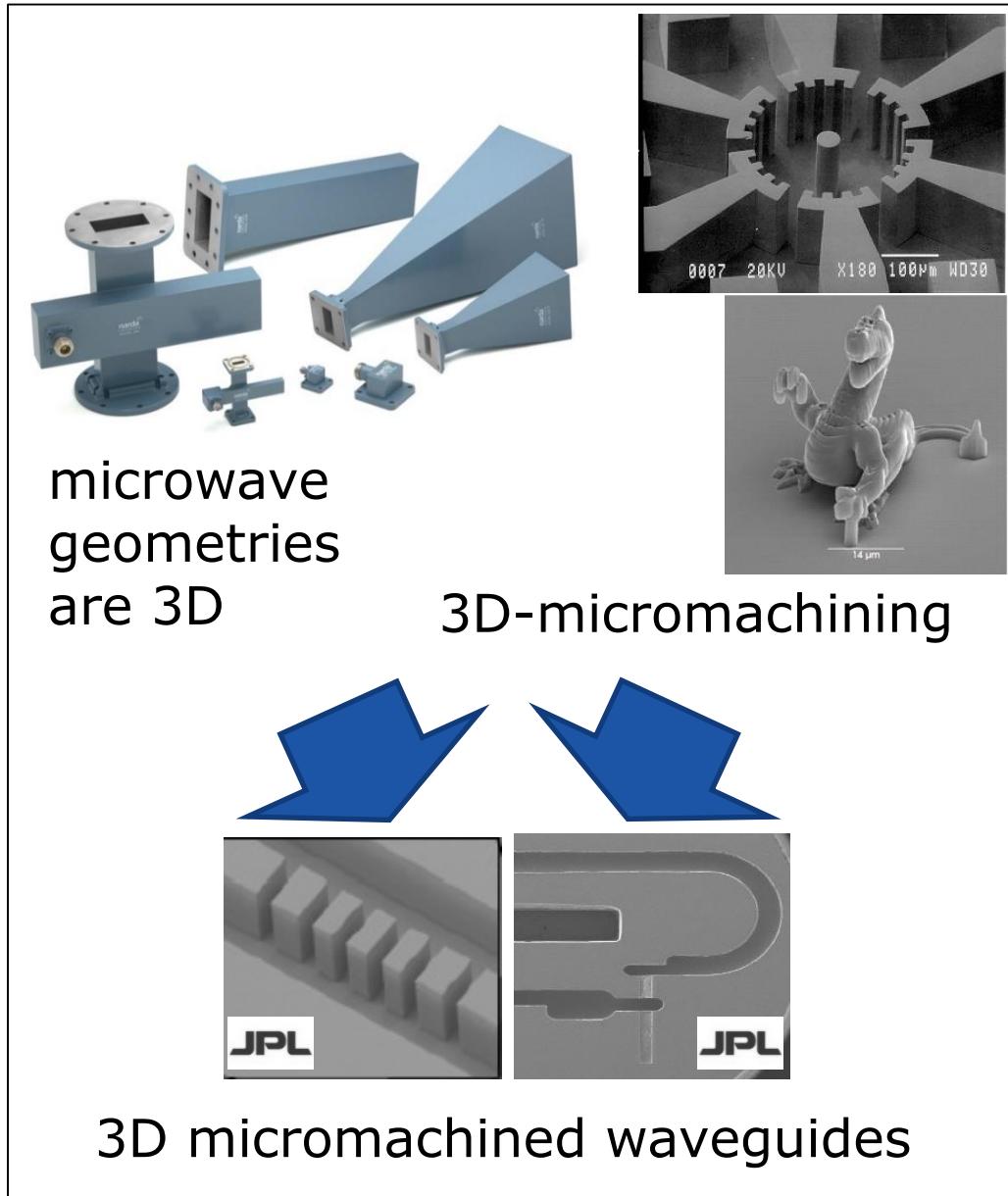
ROYAL INSTITUTE
OF TECHNOLOGY



RF (radio-frequency) MEMS:
mobile phone antenna tuners,...



? **THz MEMS revolutionizing
exploitation of THz spectrum ?**

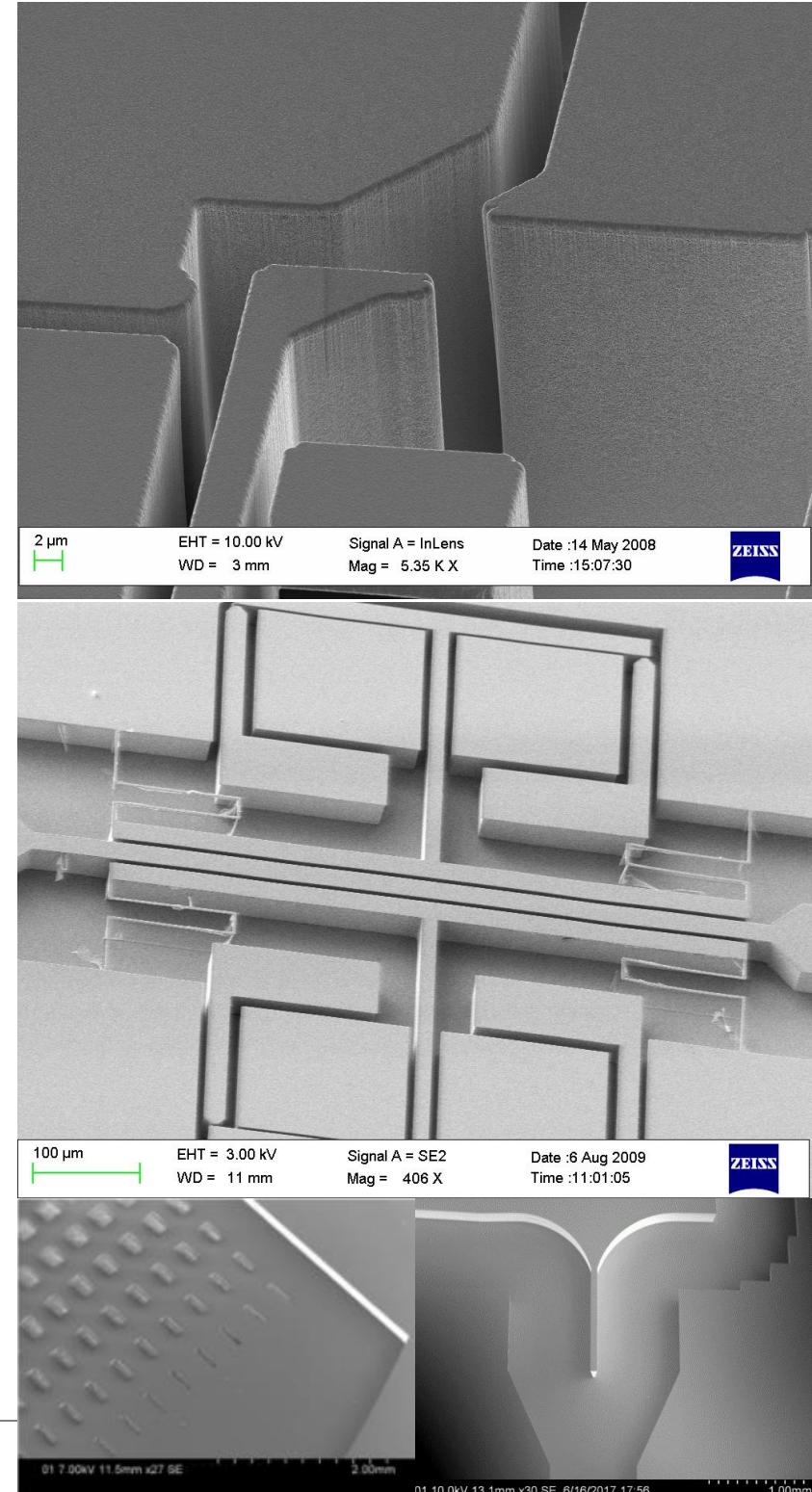


3D micromachined waveguides

Why micromachining?

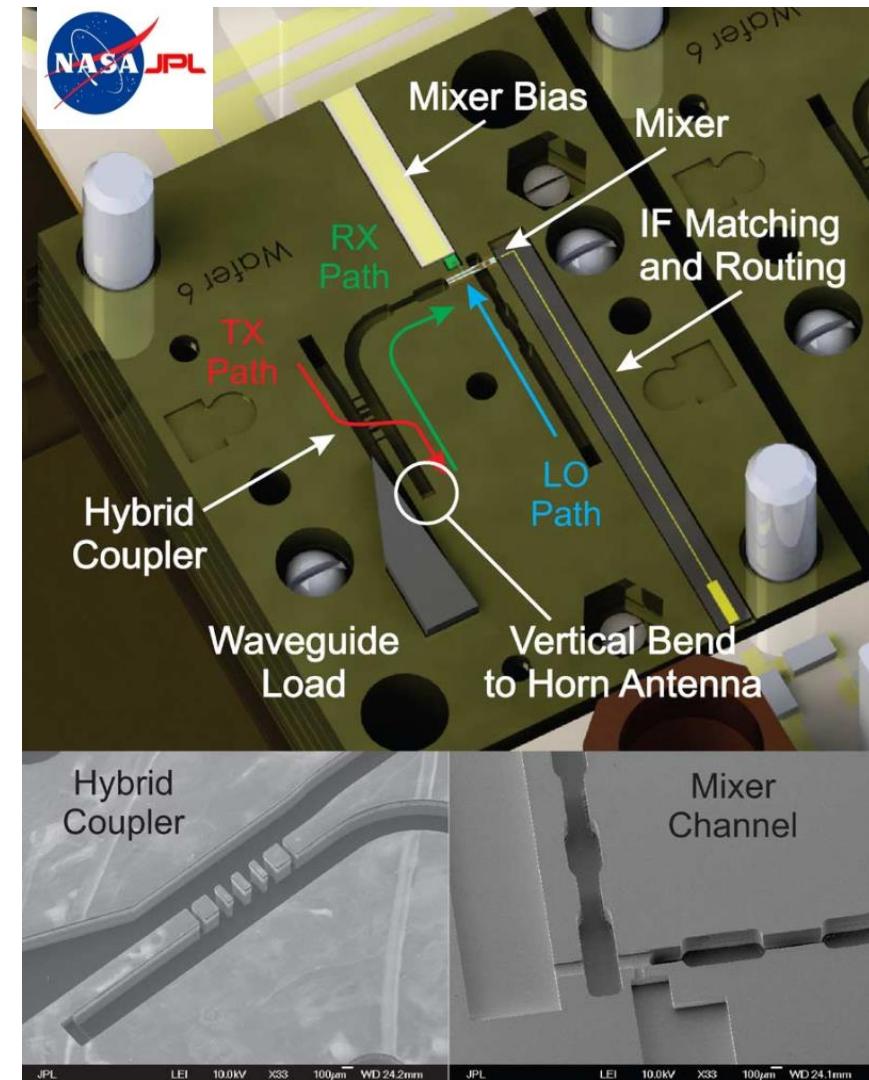
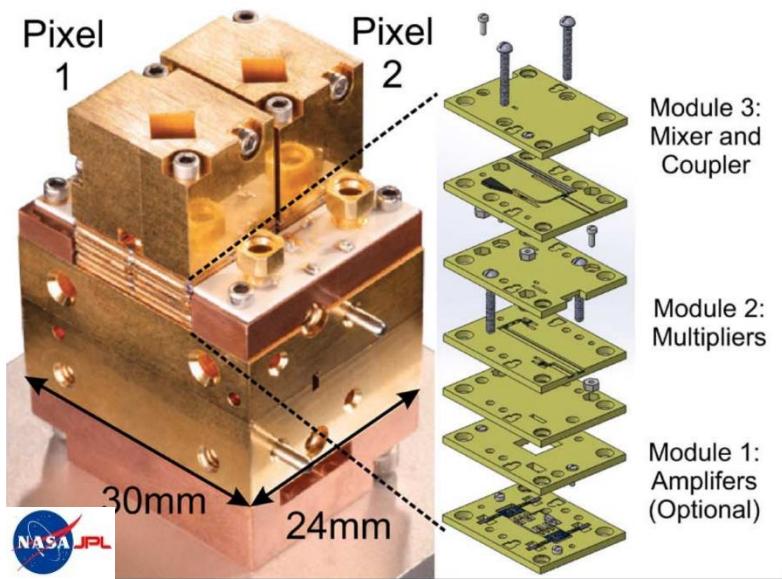
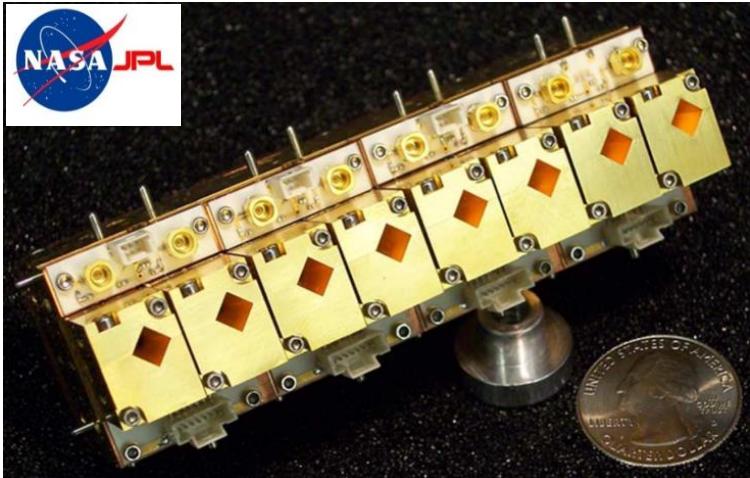
- Feature sizes/tolerances: down to μm
=> accurate geometries for THz-wavelengths
- Surface roughness: down to nm
=> ultra-low insertion loss
- Ultra-high aspect ratio geometries:
 - Vertical features: 110:1
 - Horizontal features: 1000:1
- Alignment accury: <2 μm
- Volume manufacturable
- High product uniformity
- Low cost in high volumes
- Integrated MEMS microactuators
=> reconfigurability
with near-ideal performance

Micro electromechanical systems

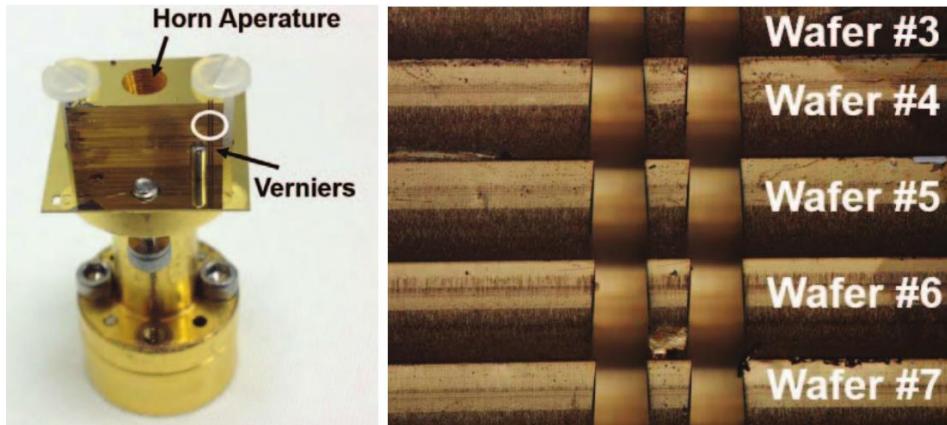
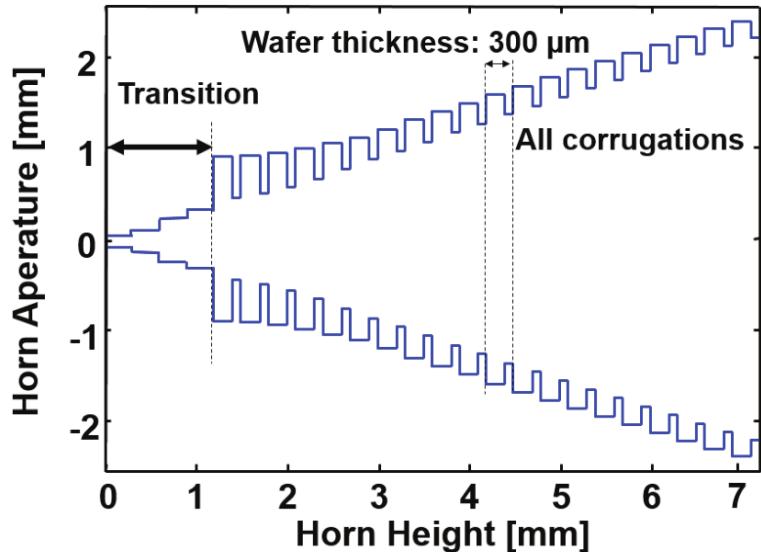


State-of-the-art THz microsystems: 340 GHz 8-pixel transceiver for imaging radar (JPL)

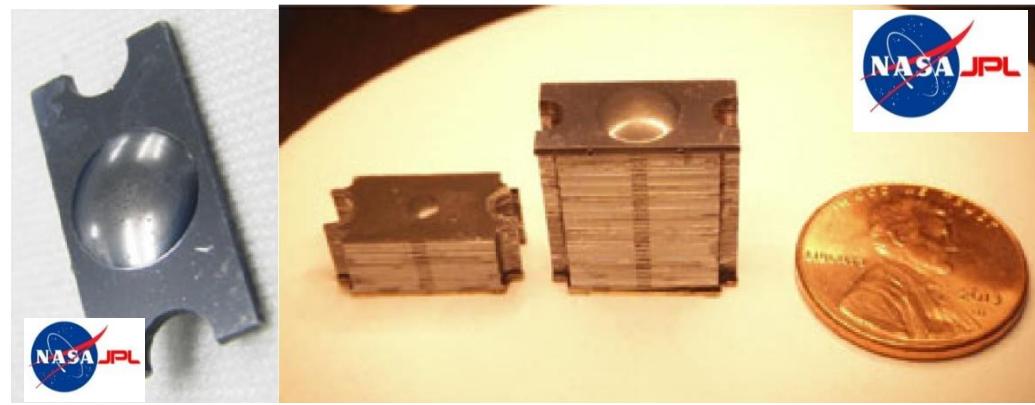
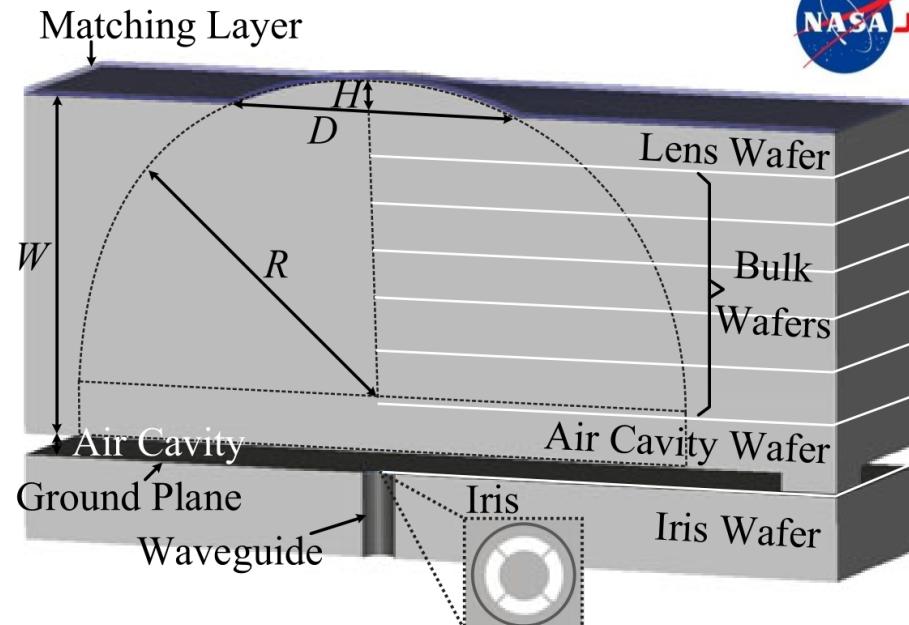
[T-THzSciTec 2015]



Micromachined THz stacked-chip antennas by JPL



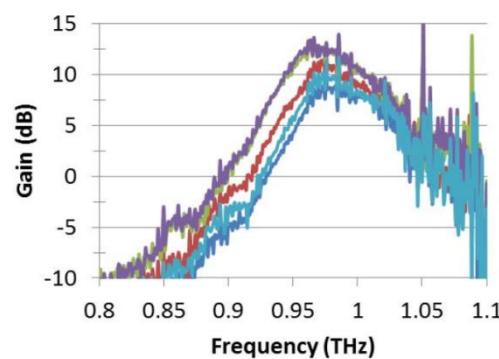
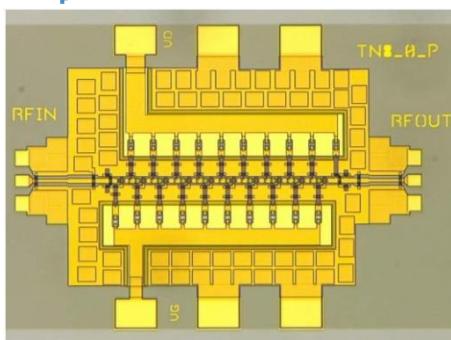
By 24 stacked micromachined silicon chips, 340 GHz, 20 dBi gain [JPL, 2015]



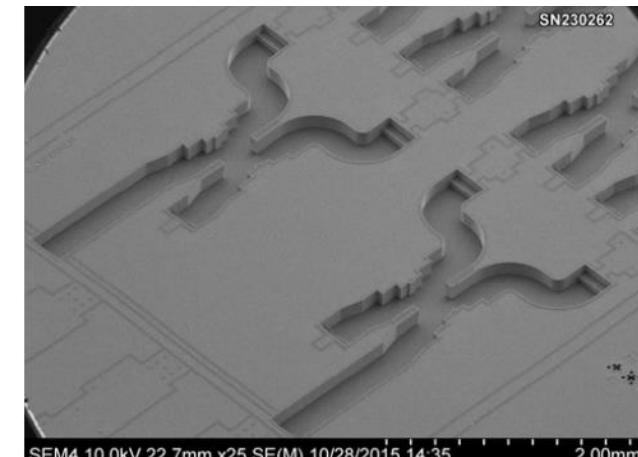
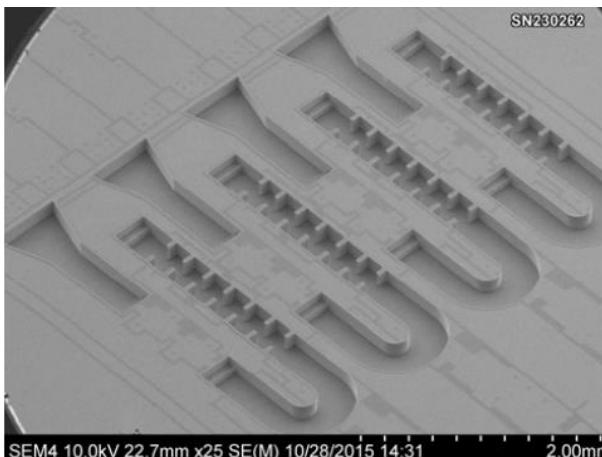
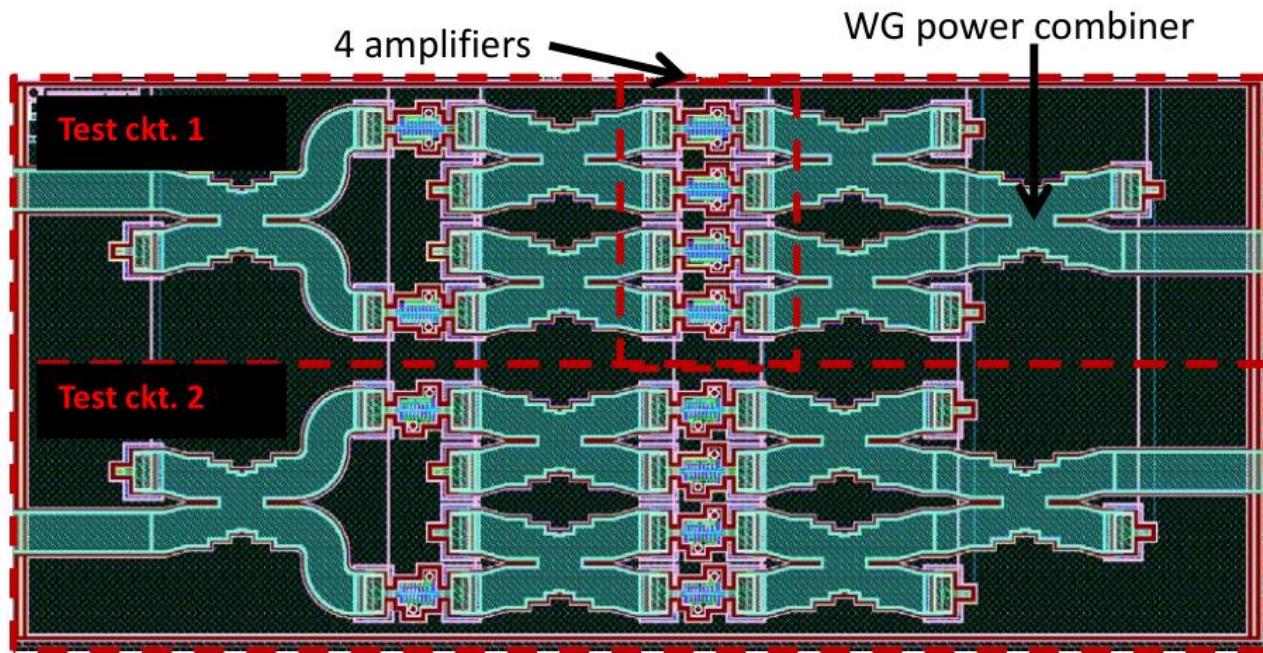
1.9 THz, narrow-band lens antenna [T-THzSciTec 2017]

Power-combining at 1 THz

Integrated 4-way Power Combiner



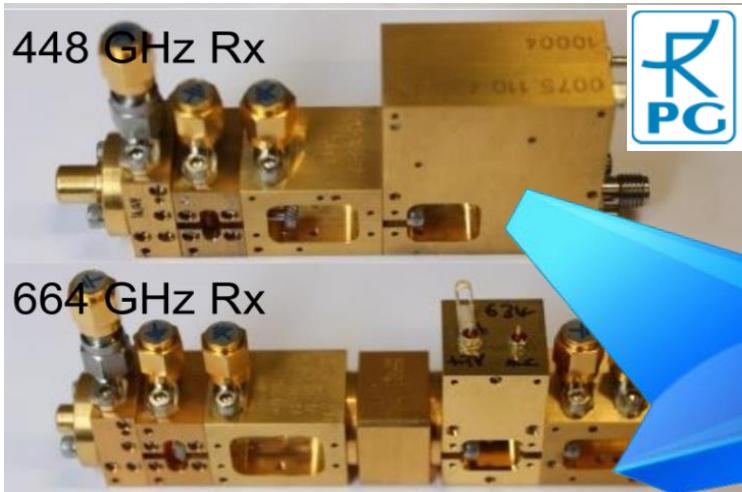
Micro-machining



0.4 mW Measured Power at 975 GHz

- Split block housings proven effective, but
- Expensive and difficult to mass produce

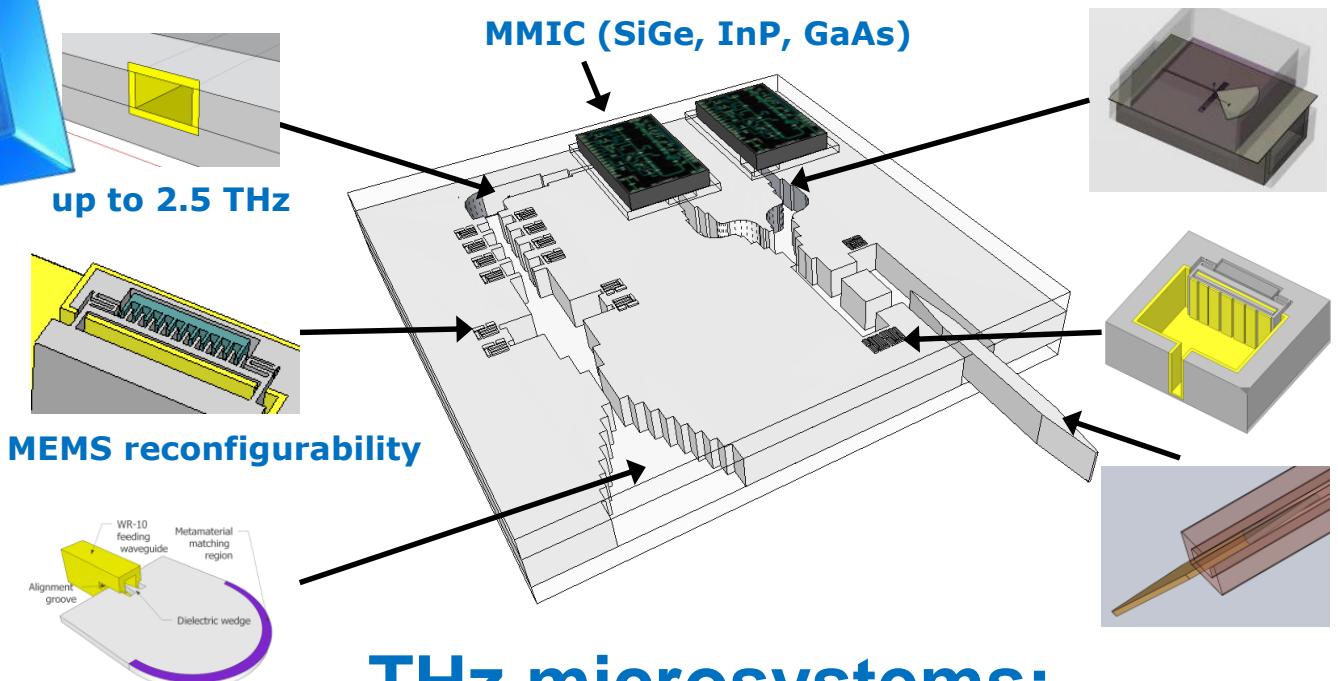
Micromachining & MEMS enabling new ways of building THz components and systems



**1000x smaller
1000x lighter
100x lower cost
10x less power consumption
reconfigurable
volume-manufacturable**

THz technology = stone age

- bulky
- heavy
- manually assembled
- expensive
- only for scientific instruments
- not volume manufacturable



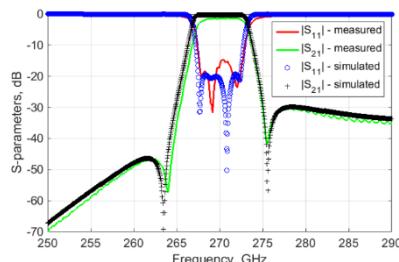
**THz microsystems:
Enabling the large-scale exploitation
of the THz frequency spectrum**

Micromachined THz Systems at KTH

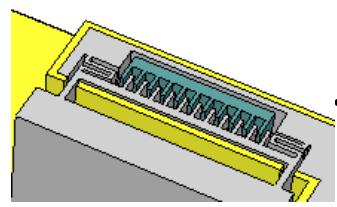
ROYAL INSTITUTE
OF TECHNOLOGY

Low loss
waveguides:

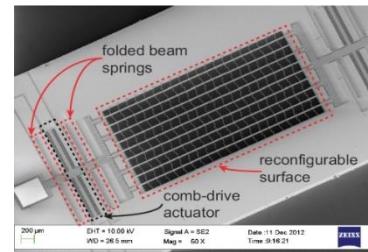
0.020 dB/mm @ 270 GHz
0.008 dB/mm @ 170 GHz



Filters: Q=800@450GHz,
Q=1600@170GHz

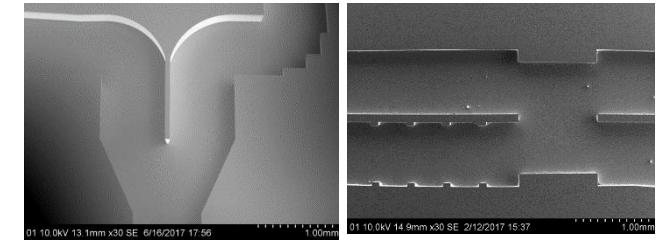
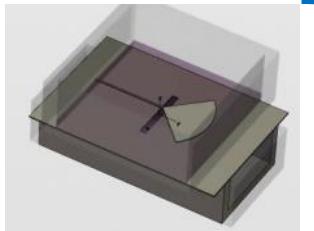


MEMS phase shifters
up to 750GHz

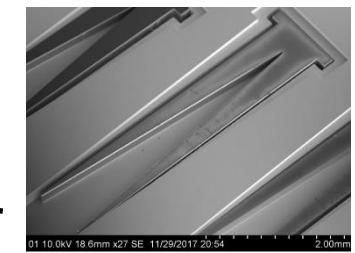


MEMS waveguide switches:
220GHz: 50dB ISO, 0.6dB IL

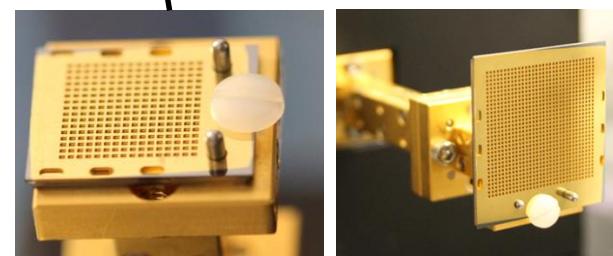
MMICs (SiGe,
InP, GaAs)
with waveguide
interfaces



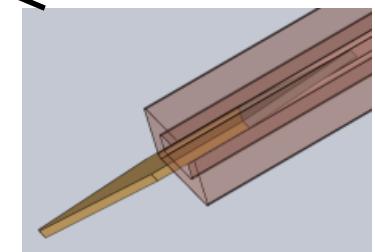
Low loss waveguide power combiners
and couplers (0.2dB IL@320GHz)



Integrated waveguide
absorbers



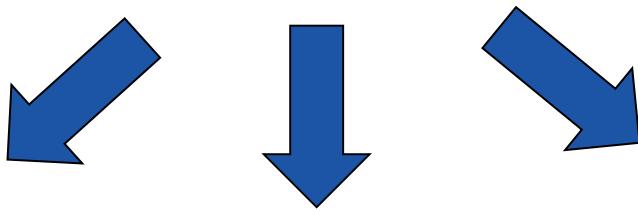
Antenna arrays, 320-400 GHz:
16x16: 34dBi gain, 0.8dB IL
32x32: 38dBi gain, 1.4dB IL



Micromachined medical
sensor interfaces

Combining competences in

Advanced micro-
wave design

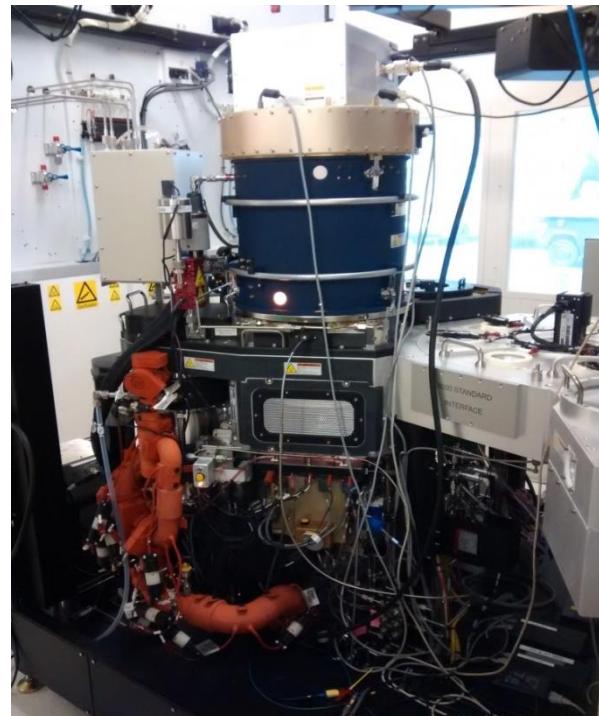


Advanced silicon
micromachining

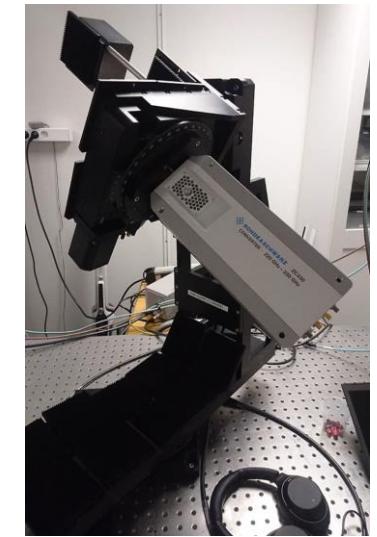
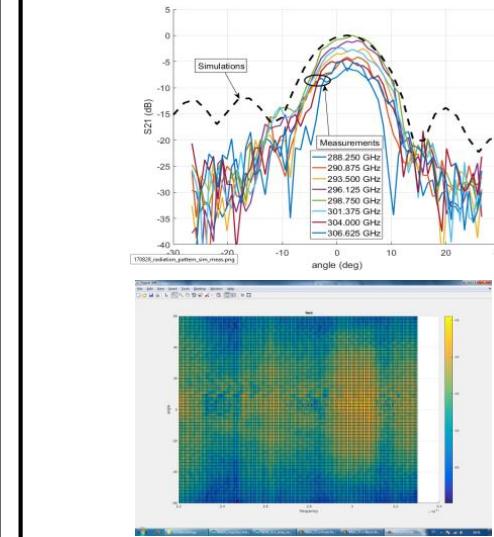
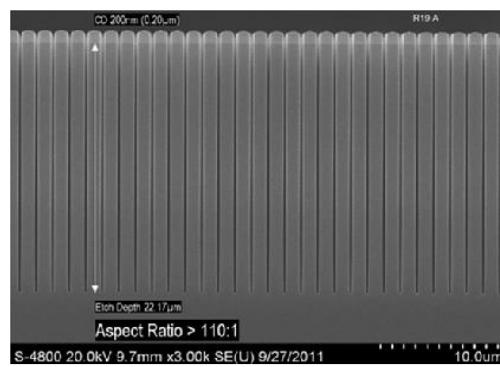
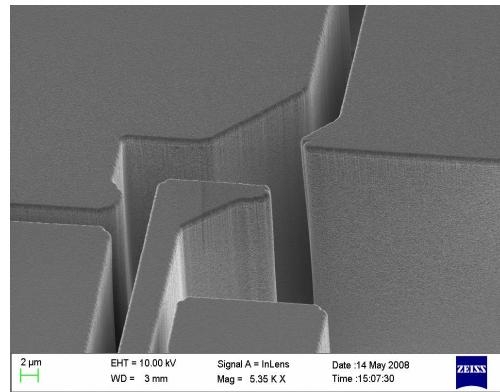
Measurements &
characterization



- VNA 67-500 GHz
- Antenna robot
(4DoF) 67-500 GHz



ELECTRUM LAB
KTH & ACREO IN COLLABORATION





ROYAL INSTITUTE
OF TECHNOLOGY

Examples of sub-THz micromachined/MEMS devices recently implemented at KTH (since 2015)

Basic components:

- Waveguides
- Couplers, splitters, matched loads
- Waveguide switches, phase shifters
- Ultra high-Q filters

Complex components:

- Orthomode transducers
- Antenna arrays

Systems:

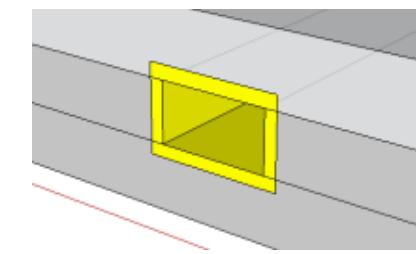
- Telecom front-end integration platform
- Beam-steering/radar demonstrators



ROYAL INSTITUTE
OF TECHNOLOGY

Micromachined waveguides

Ultra-low loss micromachined waveguides at 110-330 GHz



220-330 GHz:

0.020-0.070 dB/mm

$Q_{UL} \sim 750-800$ (270 GHz)

[IEEE THzSciTec 2018]

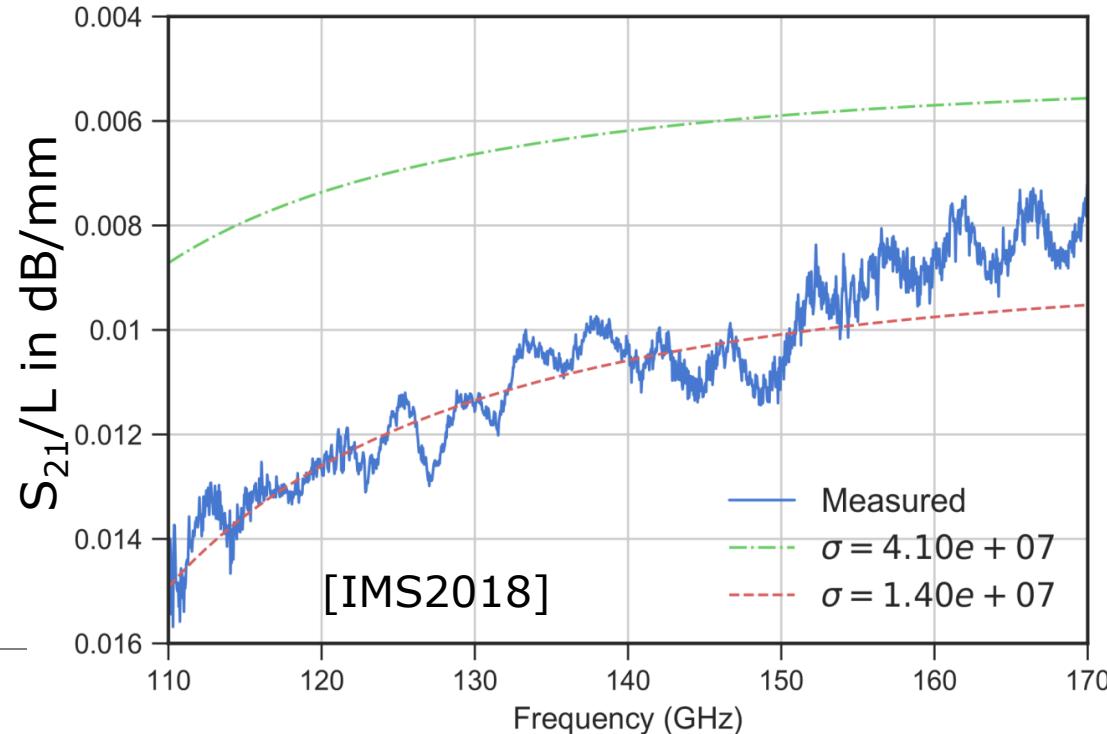
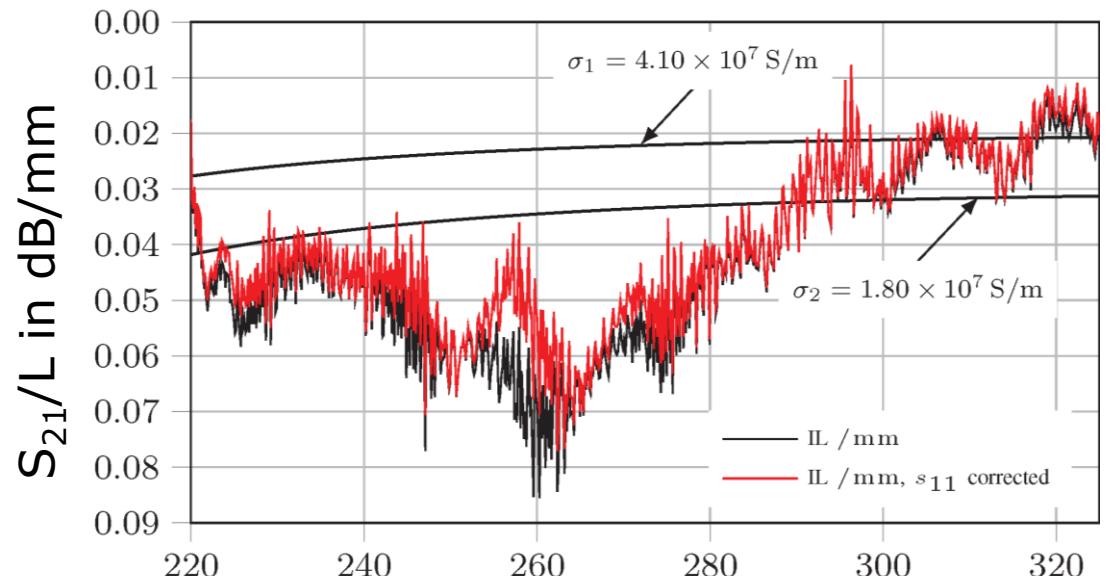
**Best performance
of any waveguide in
any technology in
these bands!**

110-170 GHz:

0.008-0.016 dB/mm

$Q_{UL} \sim 1600$

[IEEE IMS 2018]



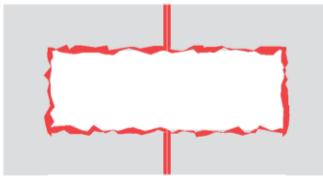
Ultra-low loss micro-machined waveguides

$$\alpha_c = \alpha_{c0} (1 + K_{rough})$$

$$K_{rough} = \frac{2}{\pi} \tan^{-1} \left[1.4 \left(\frac{R_a}{\delta} \right) \right]$$

$$\alpha_{c0} = 4.58 \times 10^{-8} \sqrt{\frac{f}{\sigma}} \left[\frac{2 \frac{b}{a} \left(\frac{f_c}{f} \right)^2 + 1}{b \sqrt{1 - \left(\frac{f_c}{f} \right)^2}} \right] dB/mm$$

Conventional approaches:

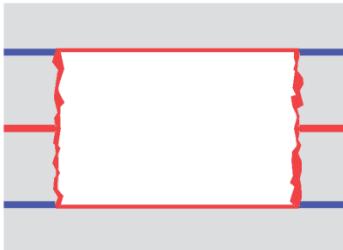


E-plane split



Single H-plane split

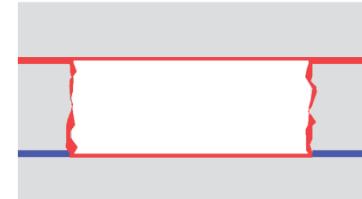
New approach: Double H-plane split



110-170 GHz:

0.008-0.016 dB/mm

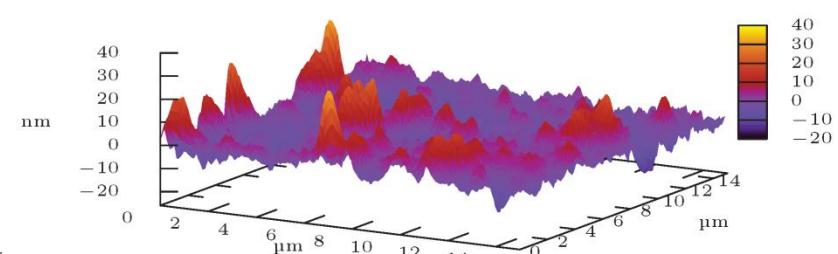
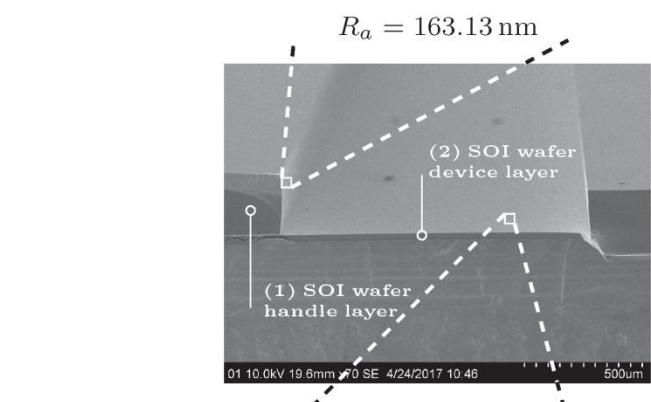
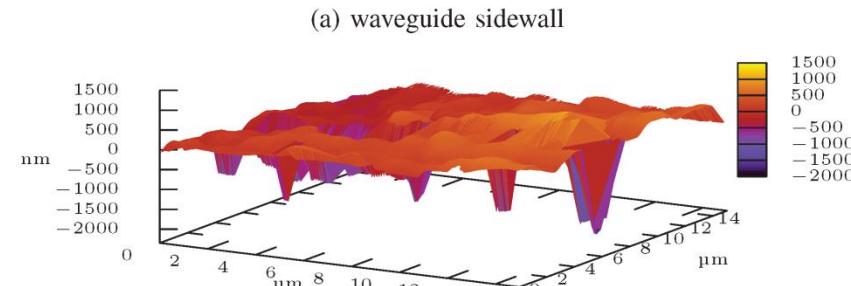
$Q_{UL} \sim 1600$



220-330 GHz:

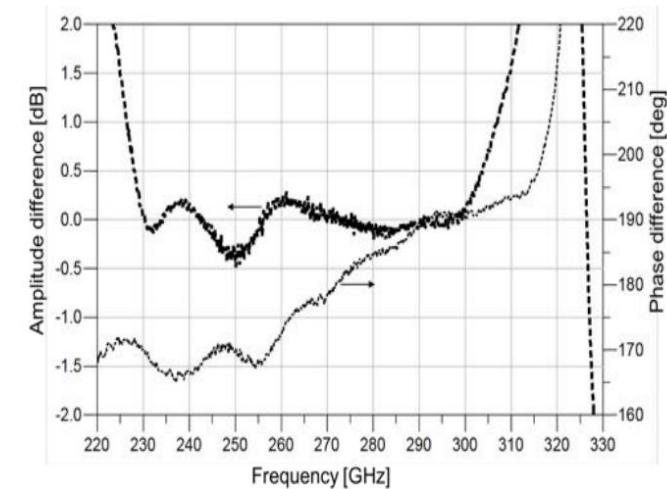
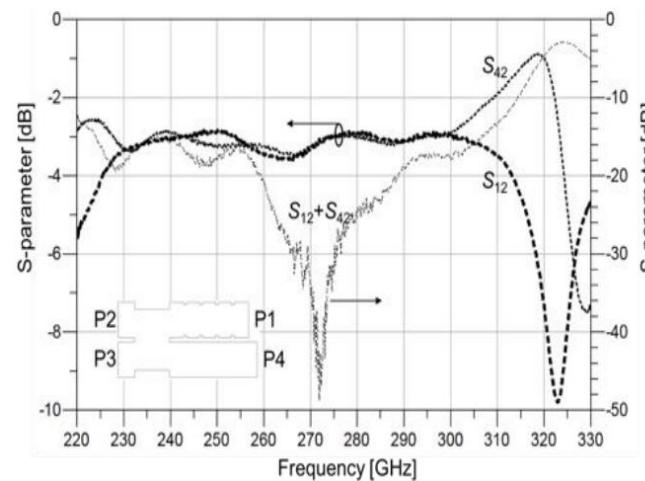
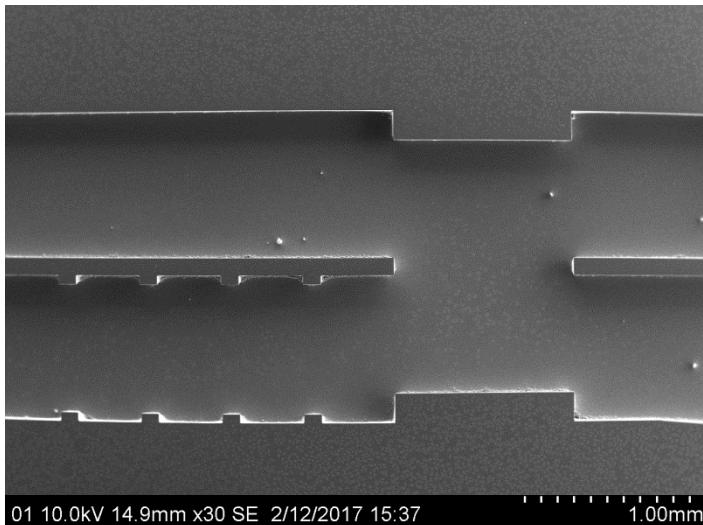
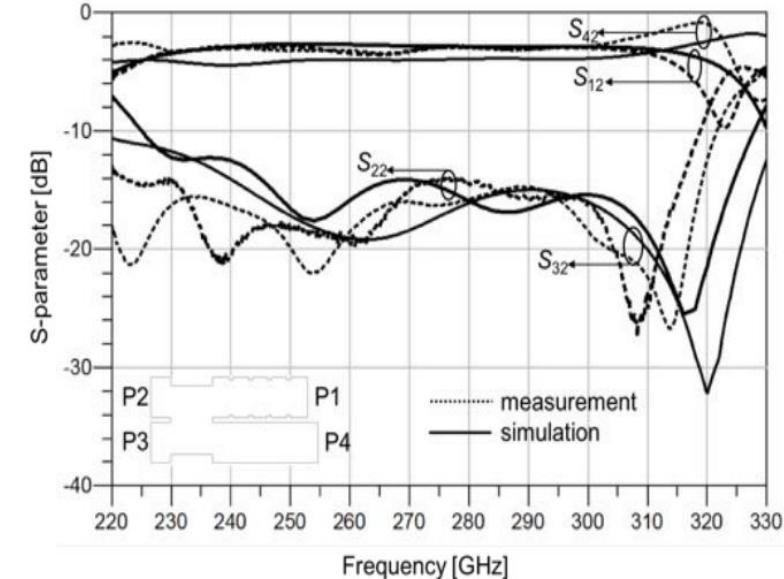
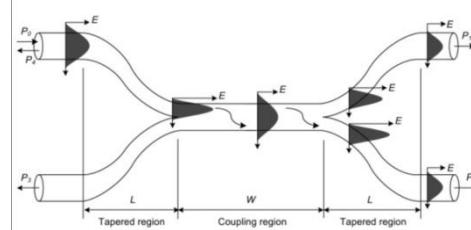
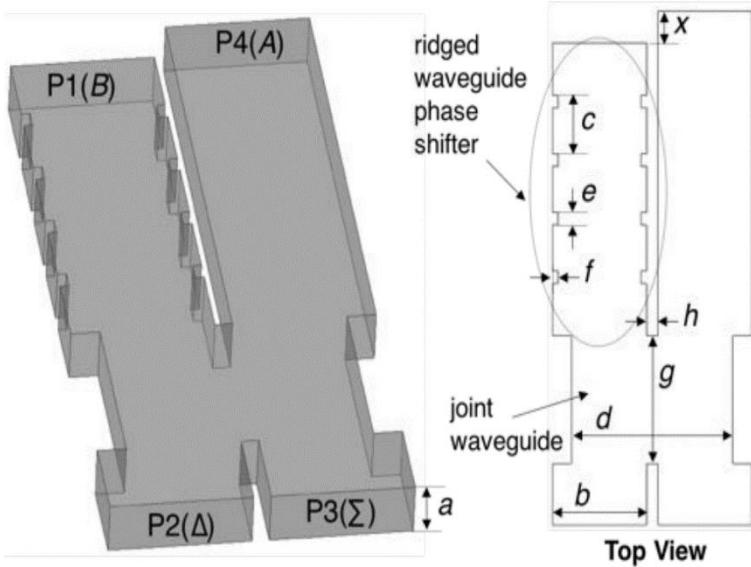
0.020-0.070 dB/mm

$Q_{UL} \sim 750-800$

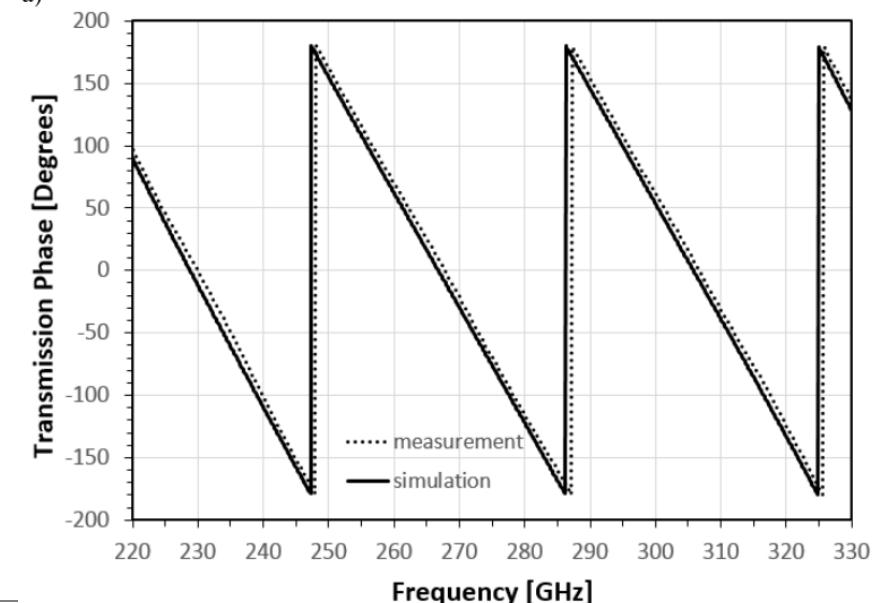
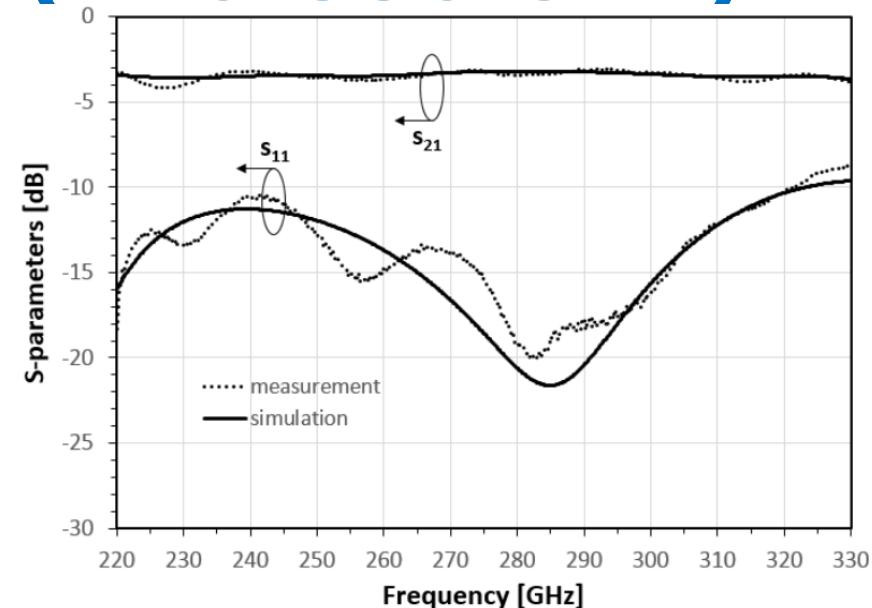
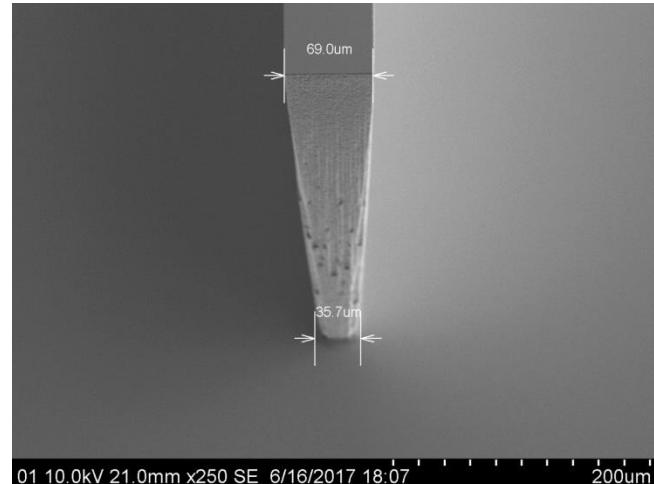
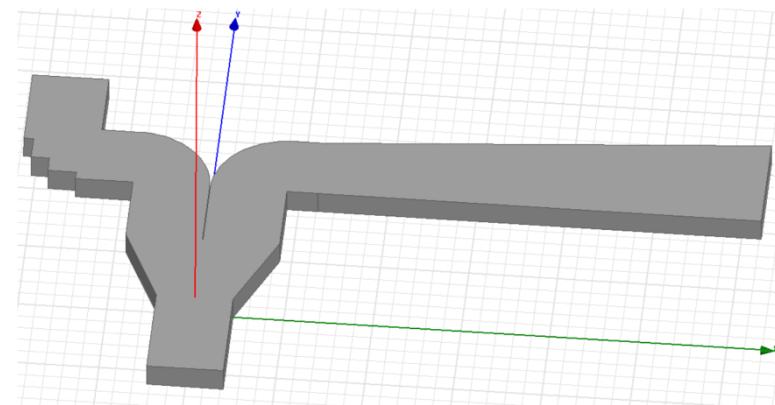
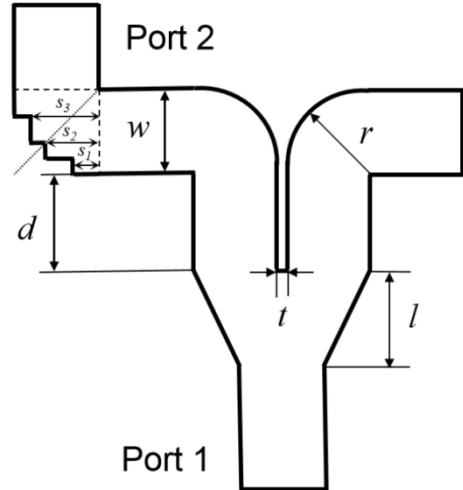


(b) waveguide top and bottom

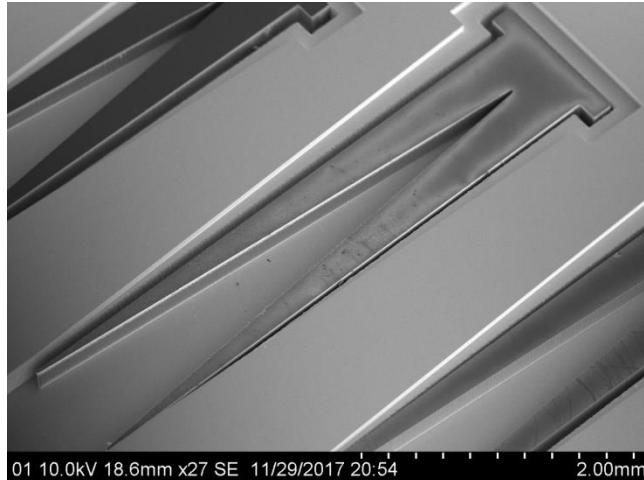
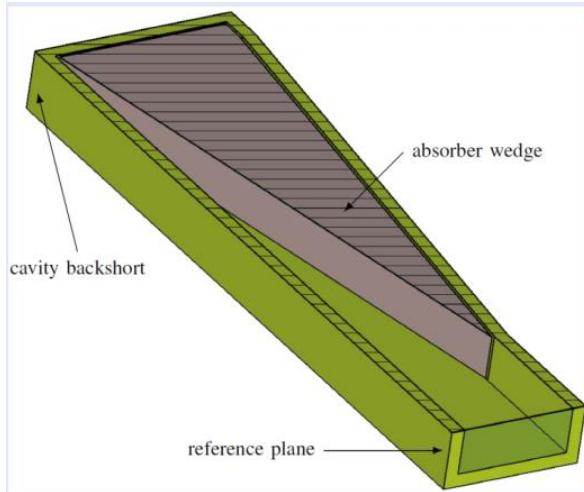
Ultra-low loss micromachined 3-dB coupler at 220-330 GHz



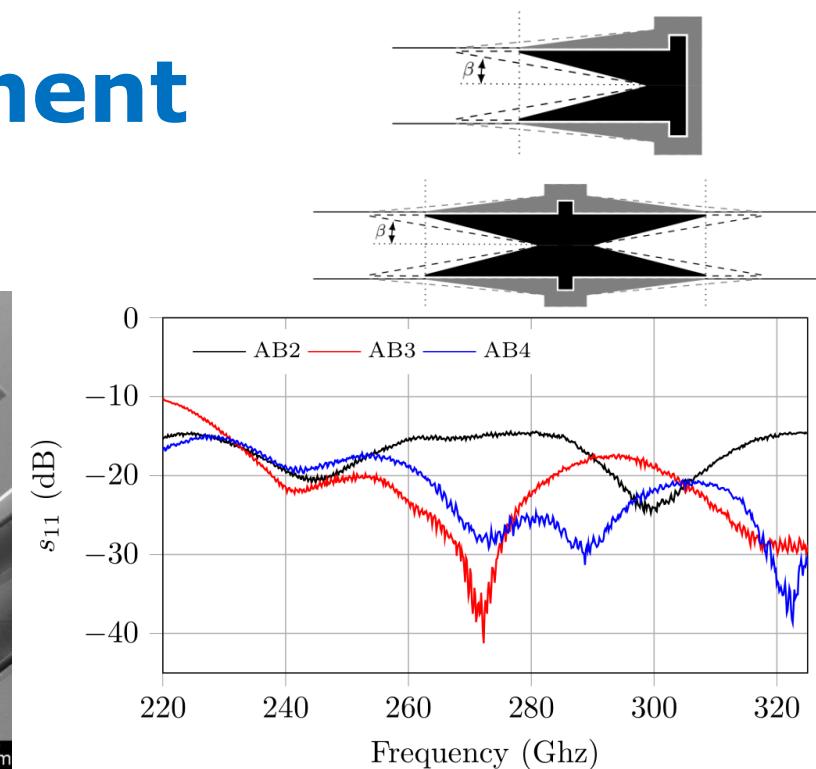
Ultra-low loss micromachined power splitter (220-330 GHz)



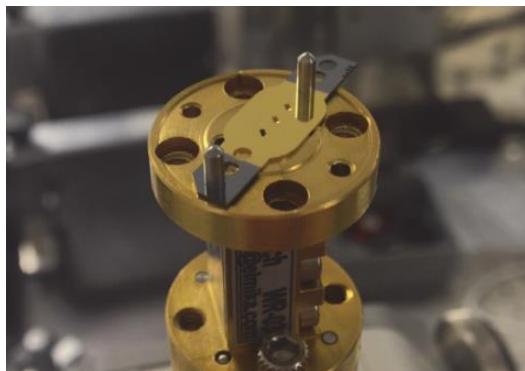
Interfaces & measurement technology



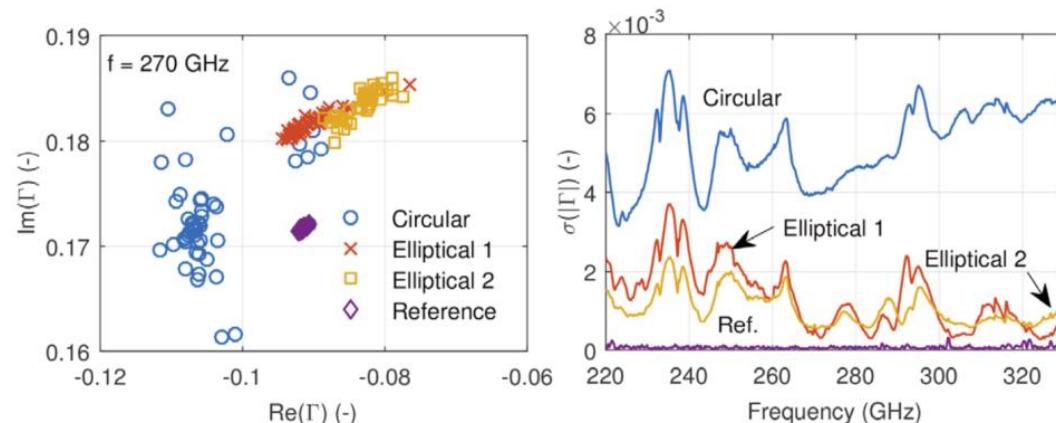
On-chip integrated absorbers, calibration kits



[EuMC 2017, IMS 2018]

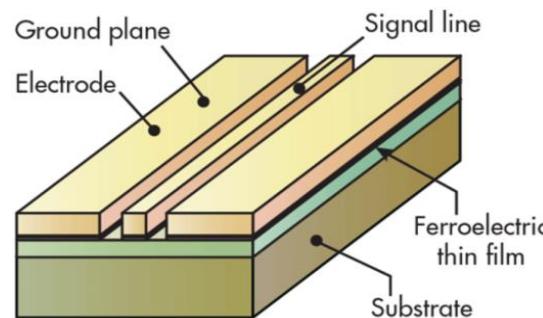


Measurement interfaces:
High-precision flange to microchip alignment method

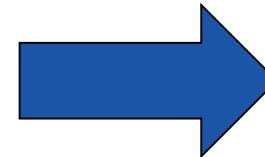


[IEEE IMS 2017]

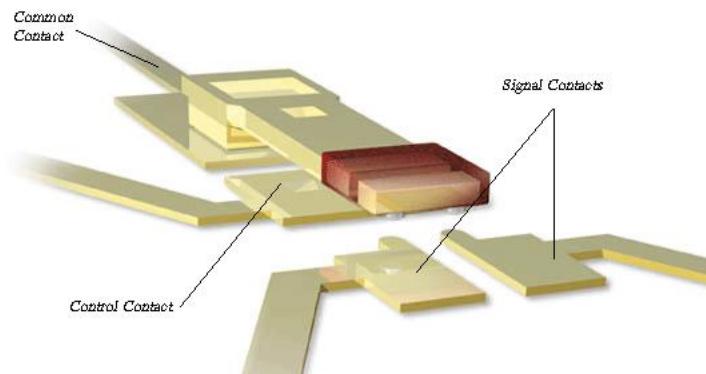
MEMS waveguide switches



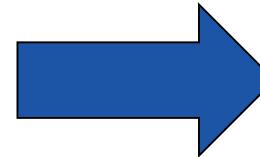
Transmission lines



waveguides

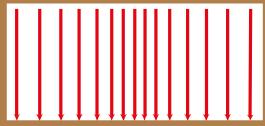


RF MEMS planar switch

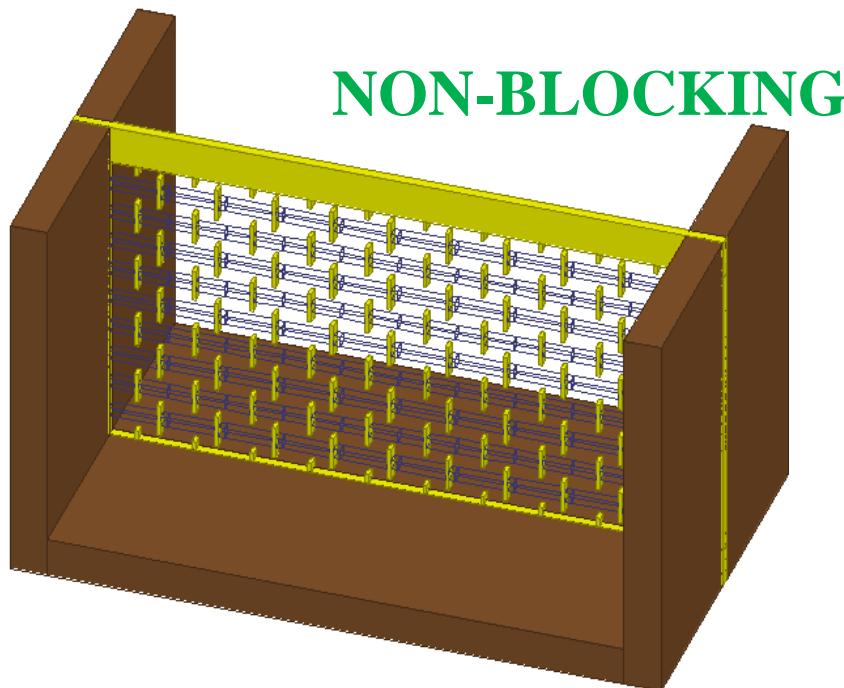
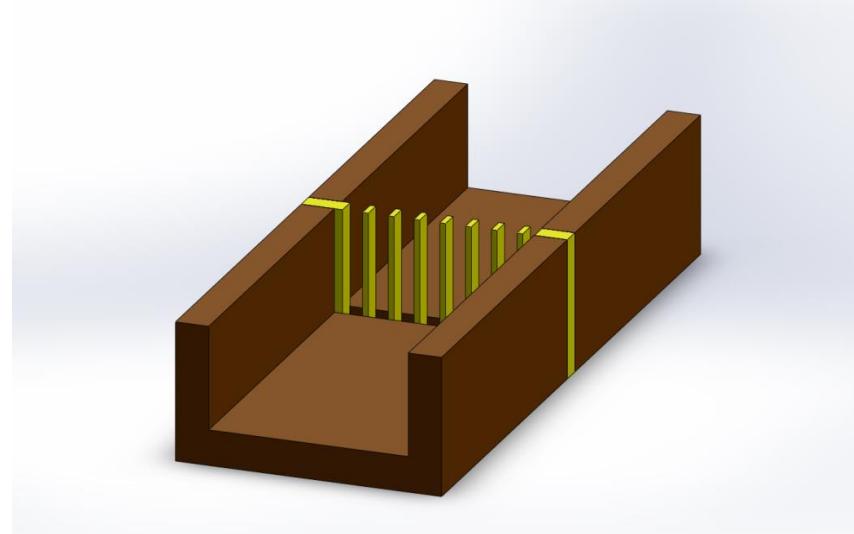


MEMS waveguide switch

How to build a MEMS waveguide switch?

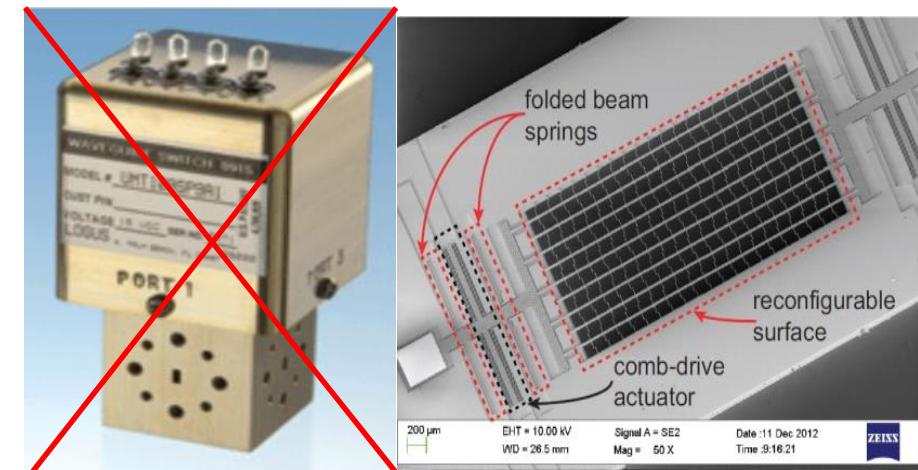


TE10 mode



MEMS:

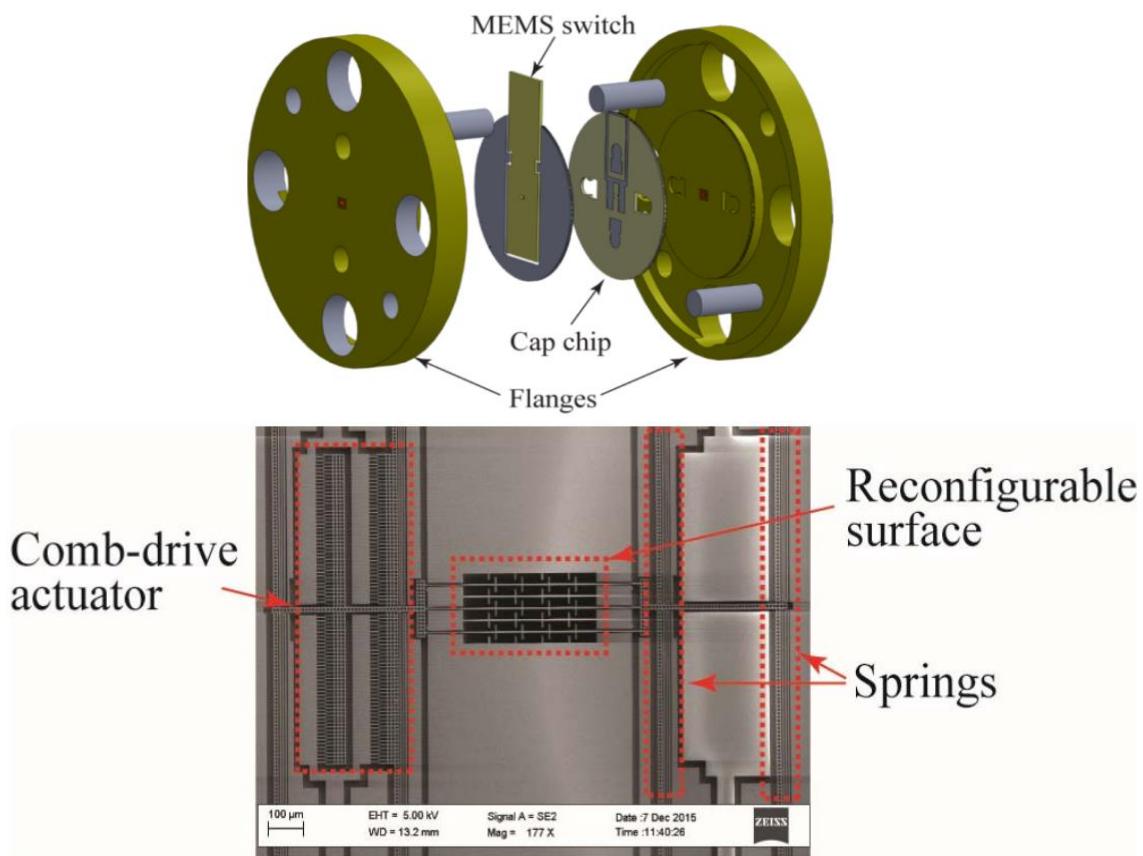
- 100 000 x smaller
- 100 000 x lighter
- 10 000 x faster
- equal performance



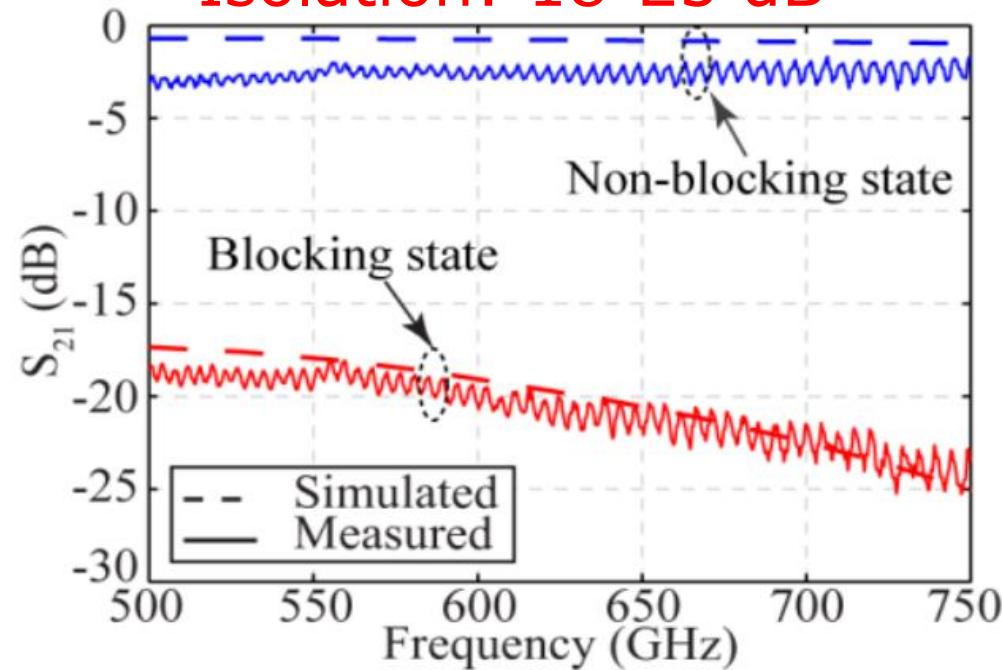
30 μm thick!
thinner than a hair

500-750 GHz MEMS waveguide switch

- First MEMS waveguide switch above 70 GHz
- First sub-mm-wave MEMS switch
- First MEMS switch above 220 GHz

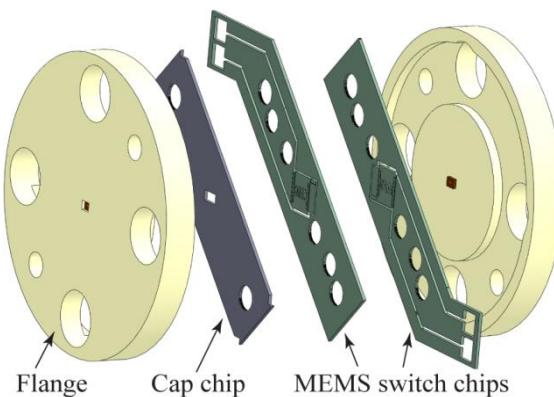


- Insertion loss: 2.5 dB
- Isolation: 18-25 dB

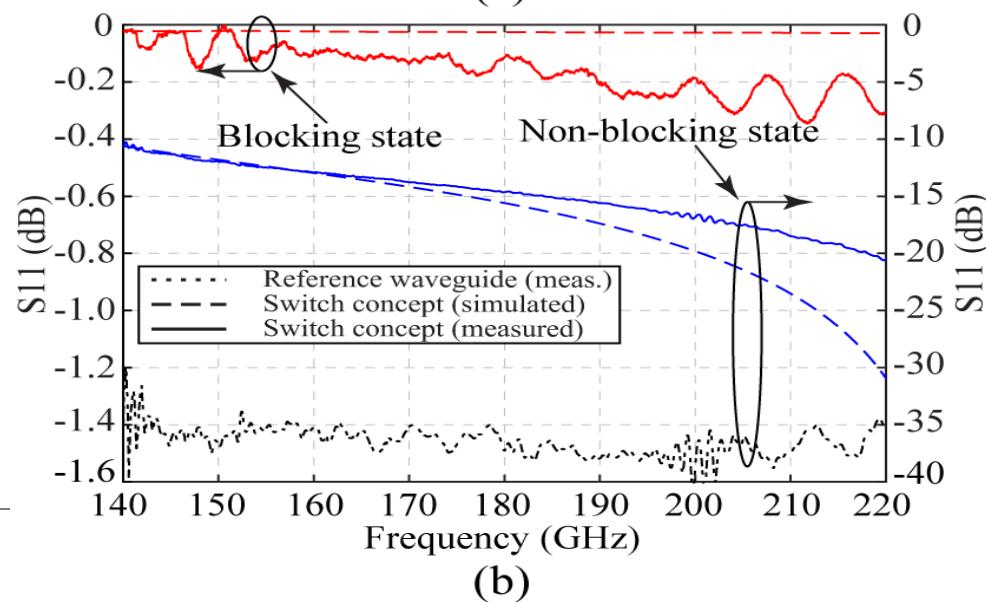
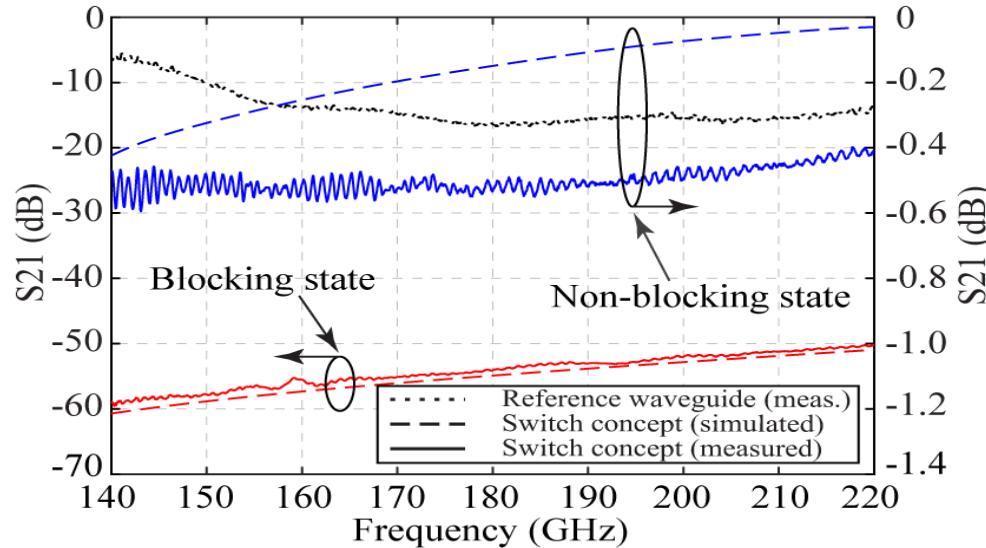


[IEEE IMS 2016, IEEE THzSciTec 2017]

High on/off ratio 183 GHz switch for radiometer calibration



Prototype measurements:



Measured performance flange-to-flange:

Insertion loss:

<0.6 dB

Isolation:

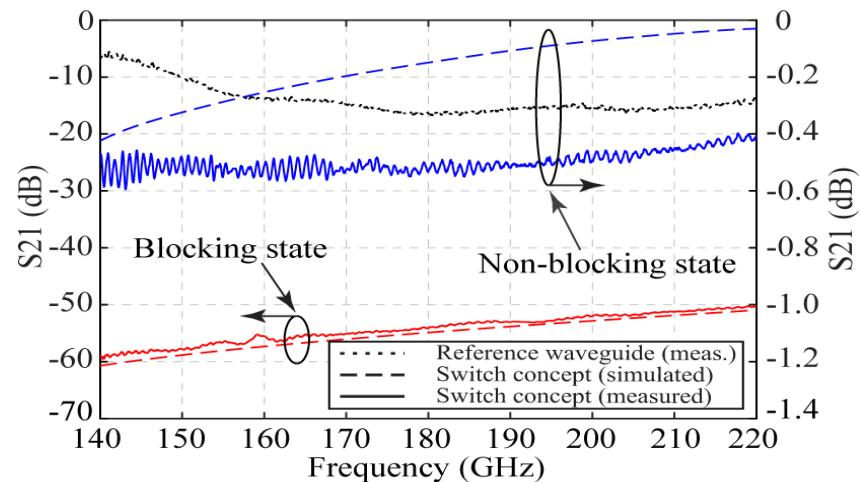
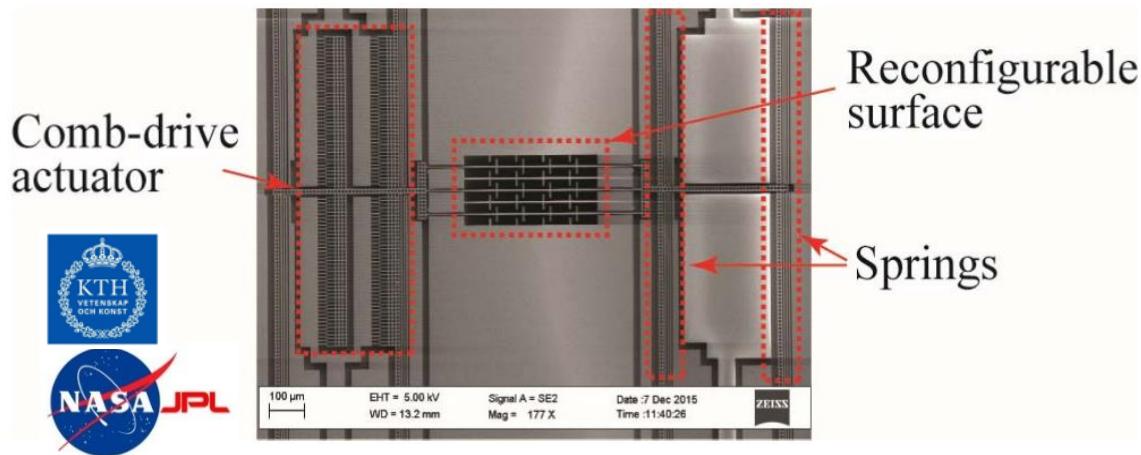
>50 dB

**For whole band
140-220 GHz**

MEMS waveguide switches by KTH

(micro electro mechanical systems)

	Generation 1 60-70 GHz	Generation 2 500-750 GHz	Generation 3 140-220 GHz
Insertion loss	0.3-0.4 dB	2.5 dB	<0.6 dB
Isolation	30-40 dB	18-25 dB	>50 dB
On/off ratio	54	9	295



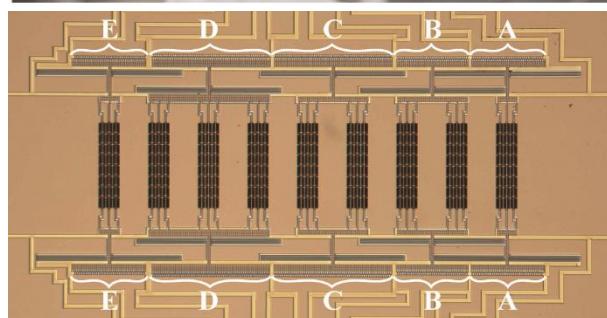
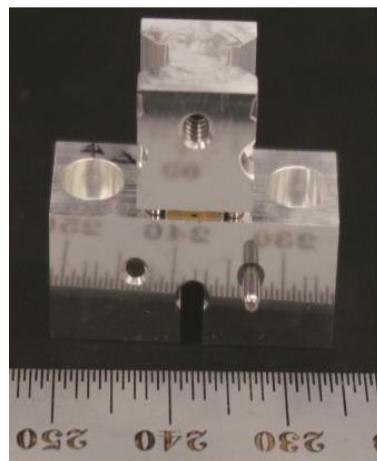
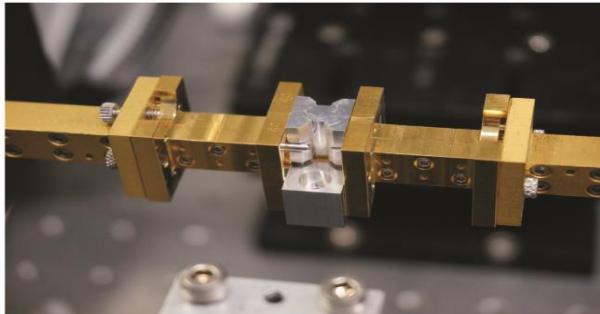
500-750 GHz switch

140-220 GHz switch



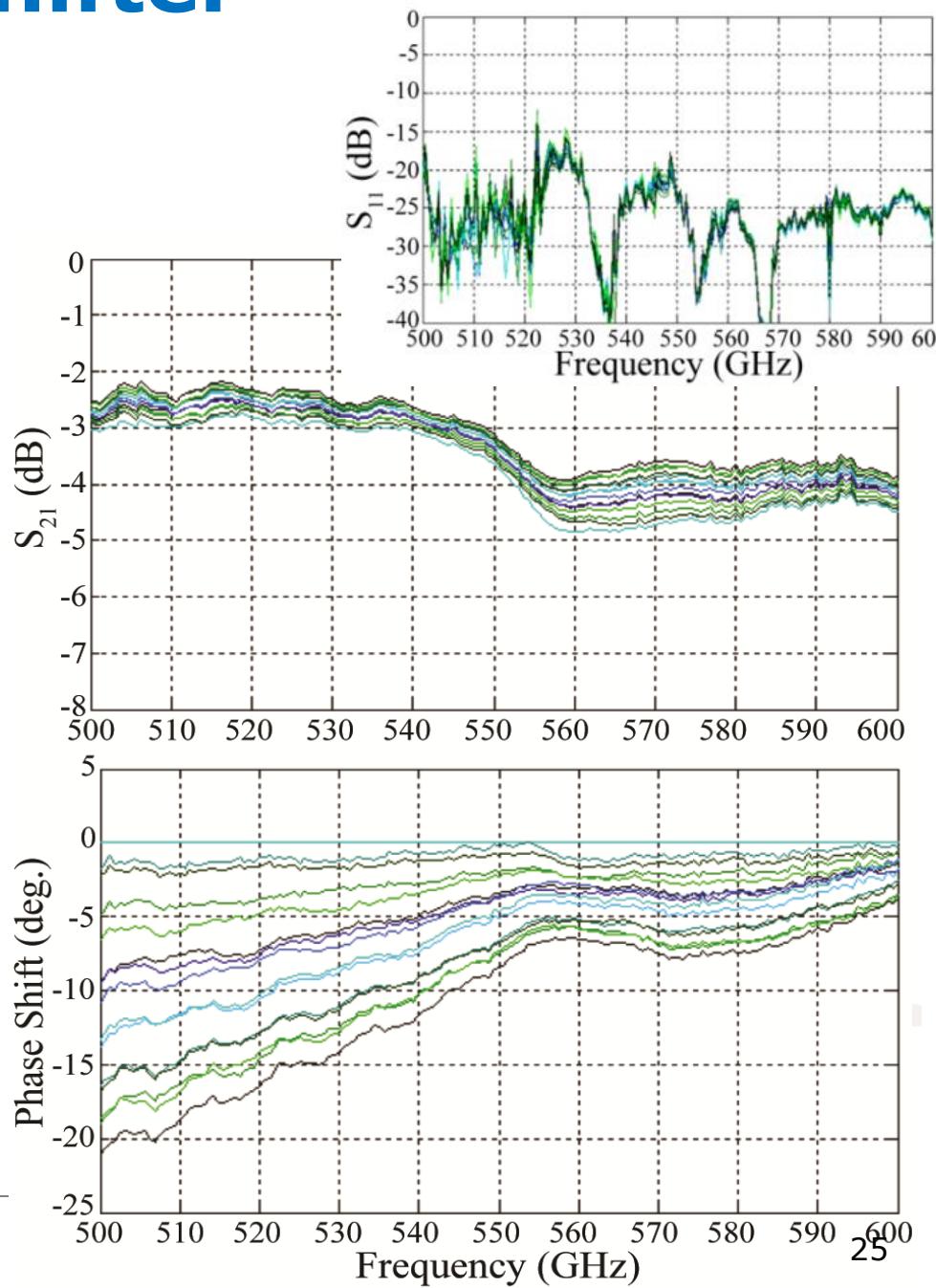
ROYAL INSTITUTE
OF TECHNOLOGY

500-600 GHz 3.3 bit MEMS phase shifter



- First sub-mm-wave MEMS circuit
- First RF MEMS above 200 GHz
- First MEMS phase shifter above 110 GHz
- First MEMS waveguide component above 70 GHz

[IEEE IMS 2015; IEEE THzSciTec 2016]

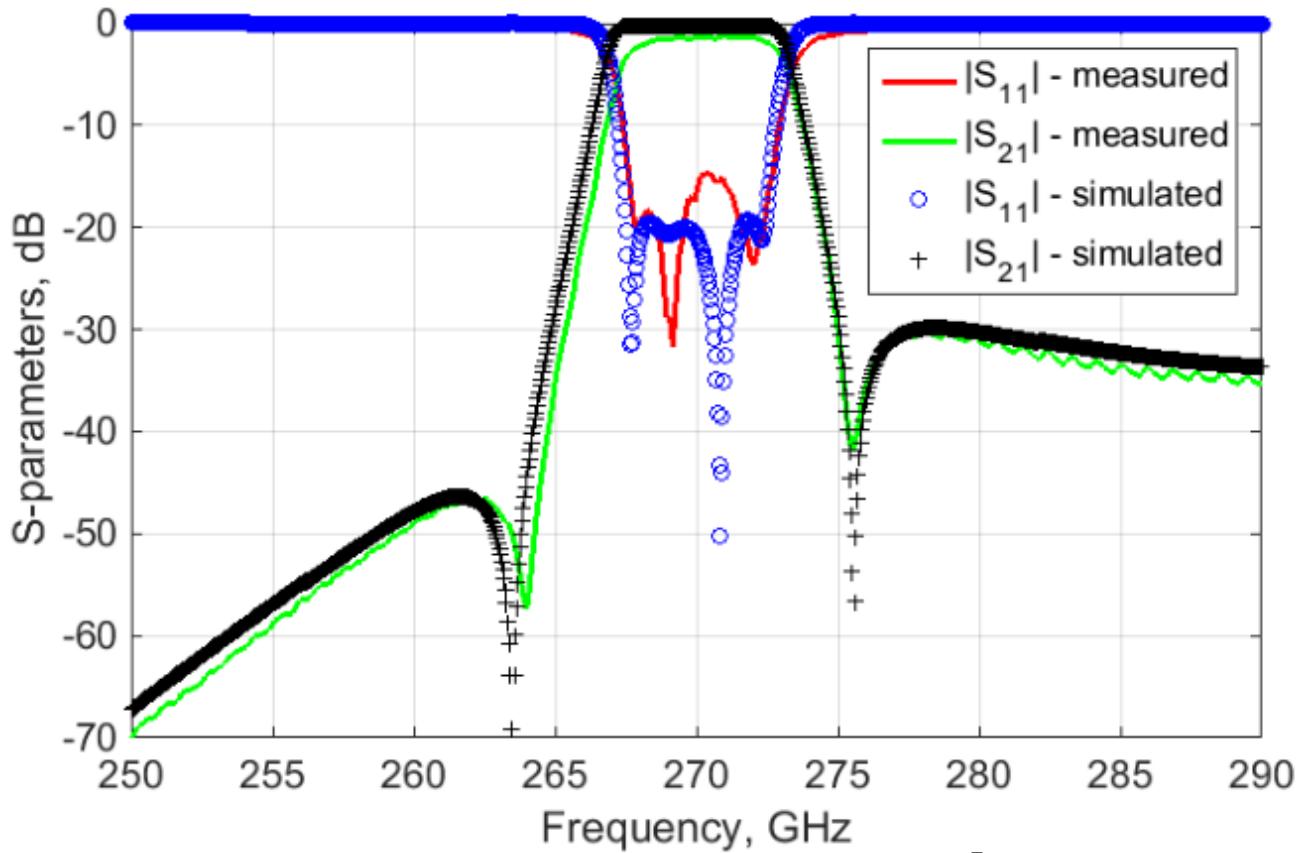




ROYAL INSTITUTE
OF TECHNOLOGY

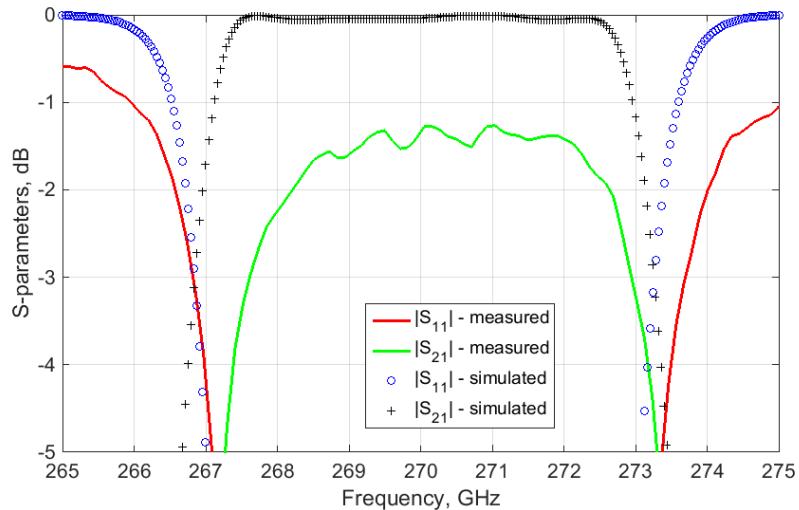
Ultra-high Q filters

KTH micromachined mm/sub-mm wave filter technology

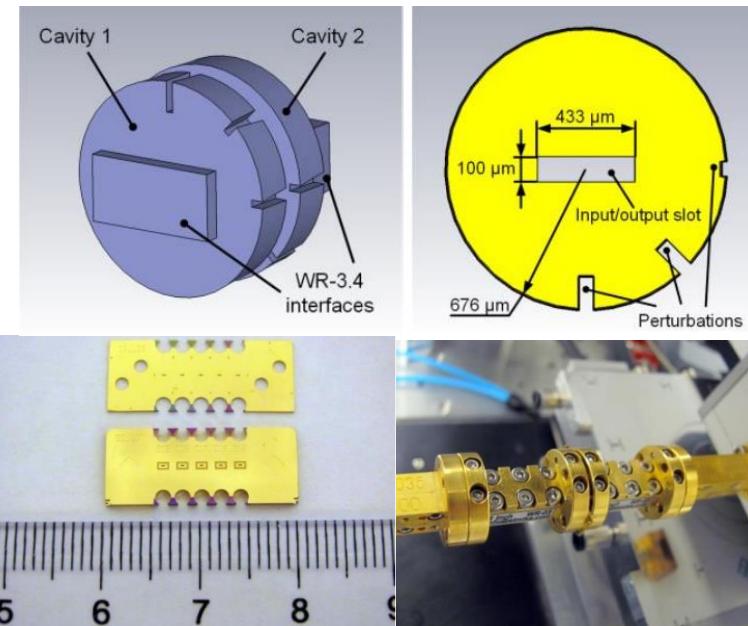


[IEEE IMS 2017]

- Best performance for any comparable filter design in any technology in this frequency band

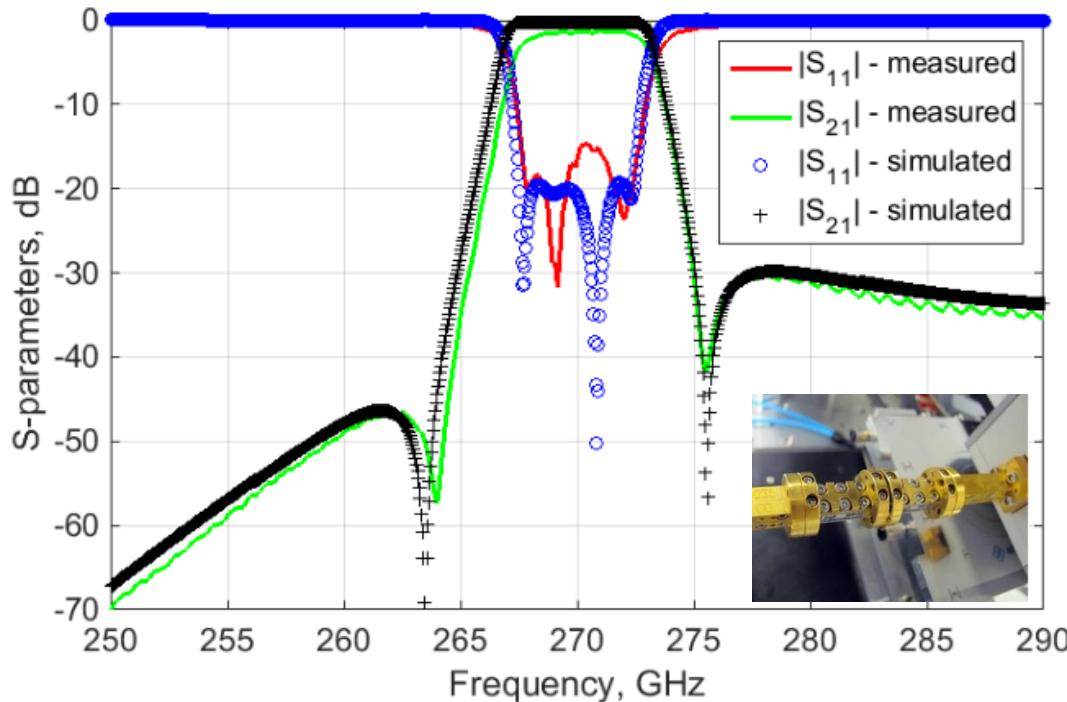


- $f_0 = 270 \text{ GHz}$, **1.85% frac. BW** (267.5...272.5 GHz)
- avg. **IL=1.5dB** (best IL=1.25dB)
- avg. **RL=-18dB** (worst = 16dB)
- rejection: >30 dB (<264, >276 GHz)



KTH micromachined sub-THz filters: best Q-factors in any technology

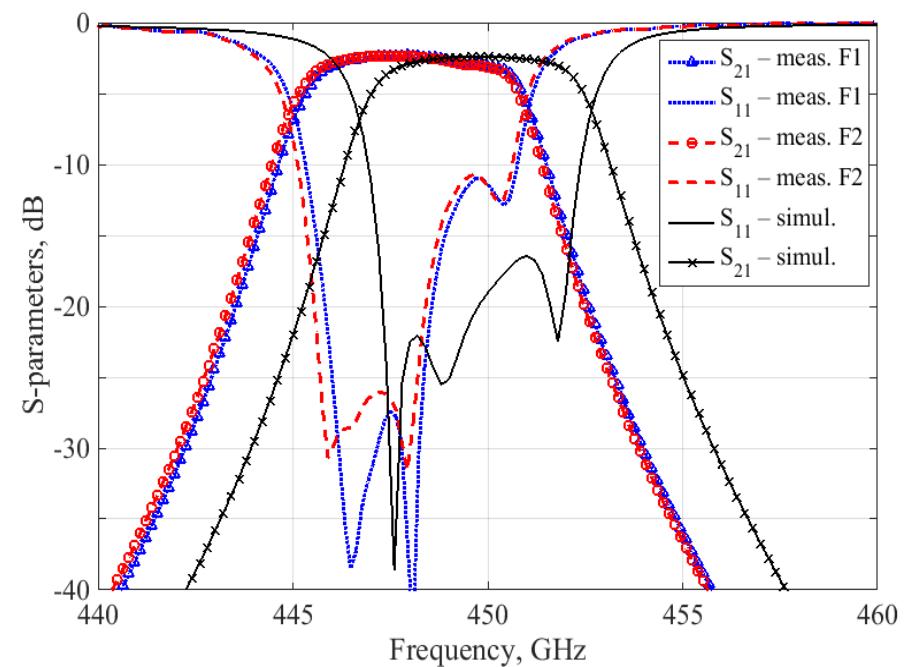
270 GHz, narrow-band:



- $f_0 = 270 \text{ GHz}$, 4p2z
- 1.85% FBW
- IL=1.5dB, RL=-18dB
- $Q_{\text{unloaded}} = 800$

[IEEE IMS 2017,
IEEE TMTT 2019]

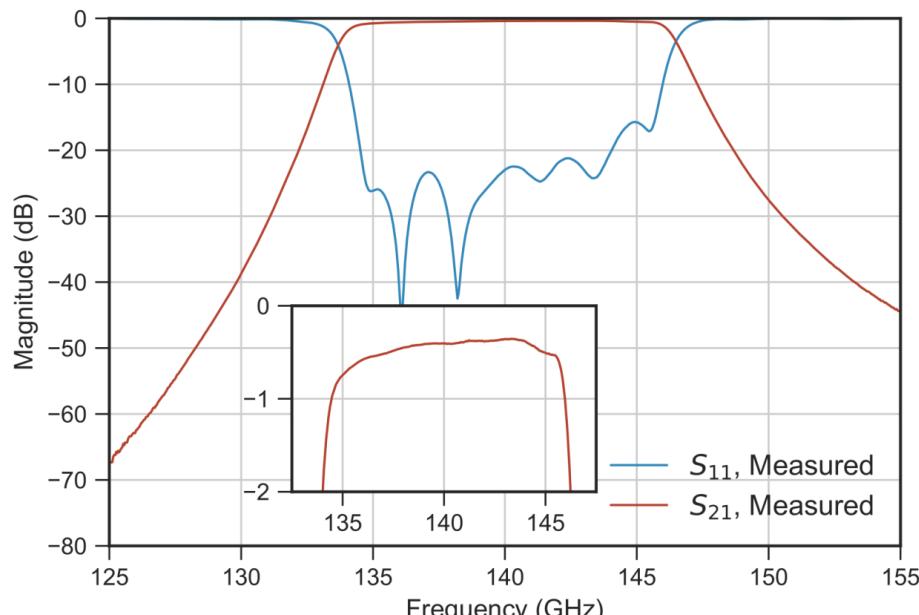
450 GHz, ultra narrow-band:



- $f_0 = 450 \text{ GHz}$, 4p
- 1.00% FBW, IL=2.5dB
- $Q_{\text{unloaded}} = 790$
- first 1%-BW filter at sub-mm wave frequencies! [IEEE TSTT, 2019]

KTH micromachined sub-THz filters: best Q-factors in any technology

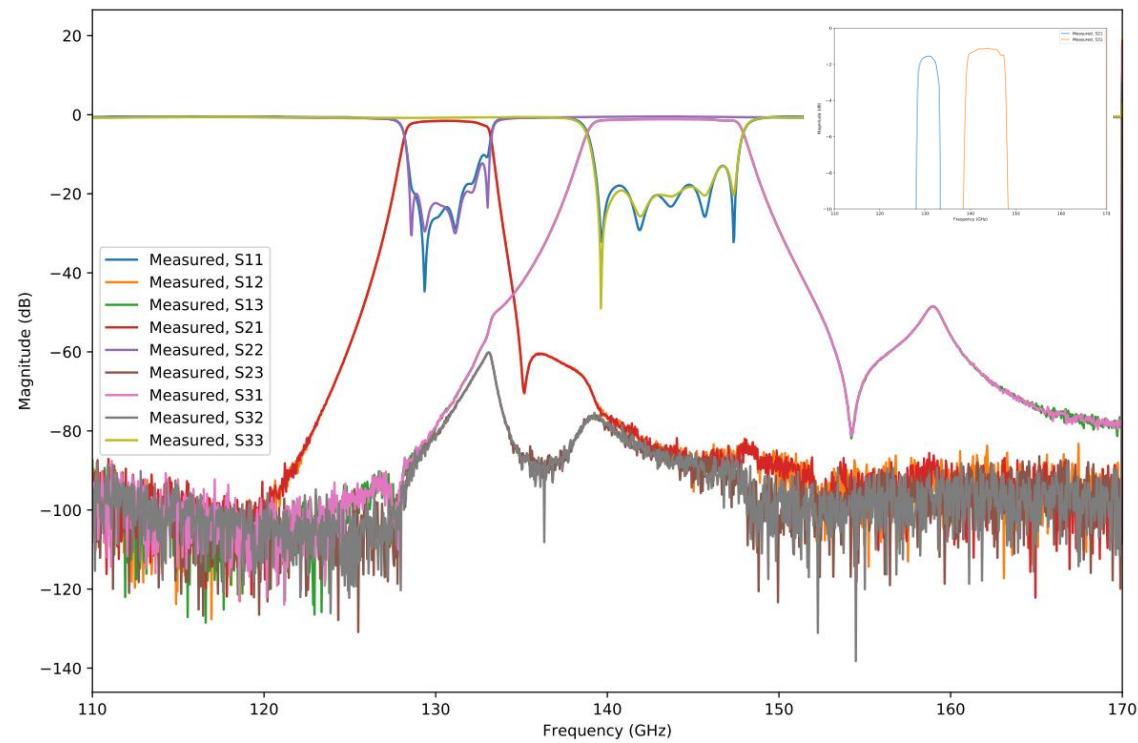
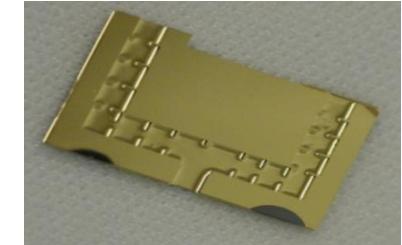
**Wide-band example:
5.2% FBW, 141-148.5 GHz**



<0.5dB IL, $Q_{UL} \sim 1600$

[IEEE IMS 2018]

**Telecom diplexer:
141-148.5,
129-134 GHz**



<1.5dB IL, >60 dB isolation



What is next? Current micromachined filter development activities

Pushing current technology:

- 700 GHz filters with 1% fractional bandwidths

New generation technologies:

- W-band (75-110 GHz) filters with Q factors >5000
- 183 GHz narrow-band filter banks with Q factors of 5000
- Fabrication-tolerance insensitive filter geometries

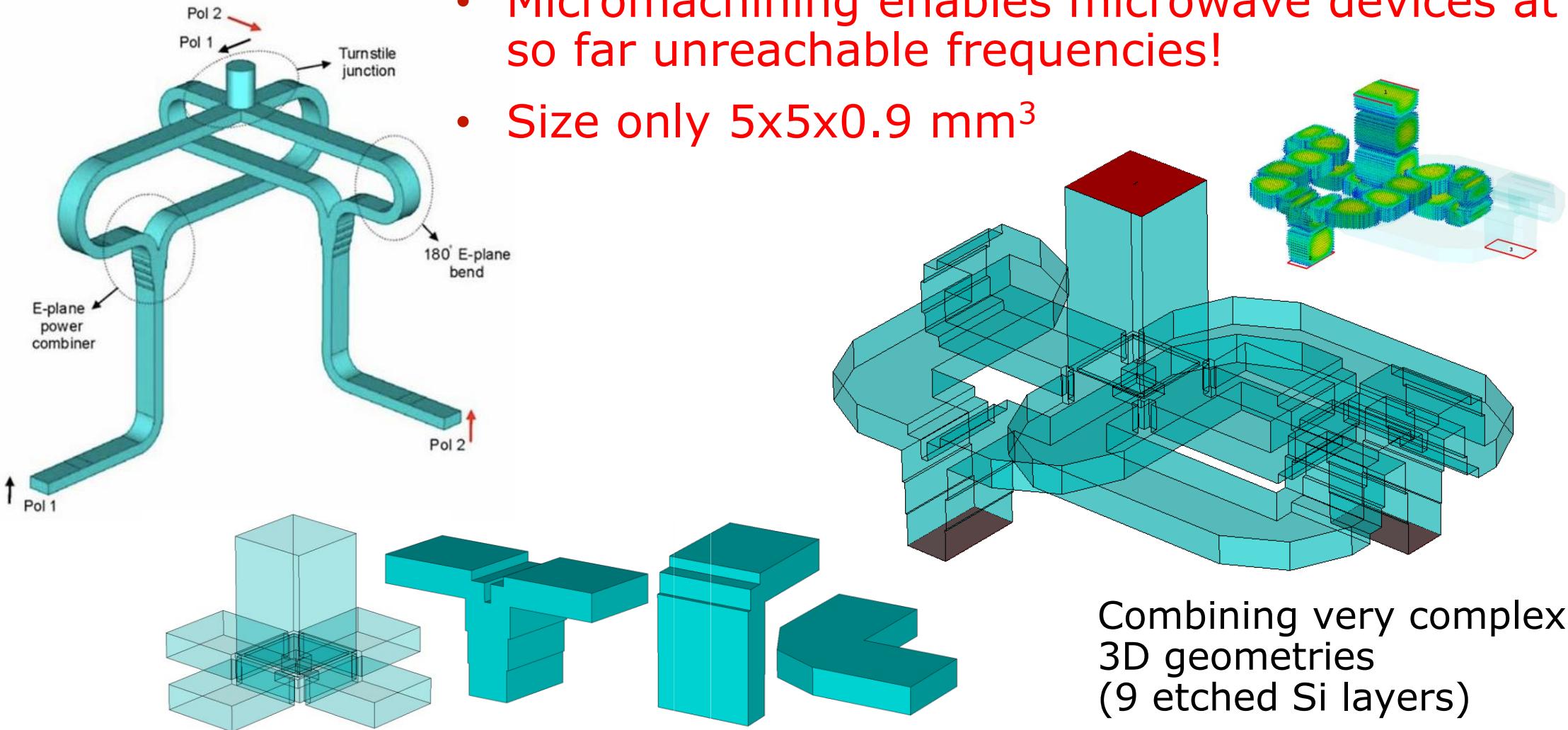


ROYAL INSTITUTE
OF TECHNOLOGY

Micromachined ortho-mode transducer (OMT)

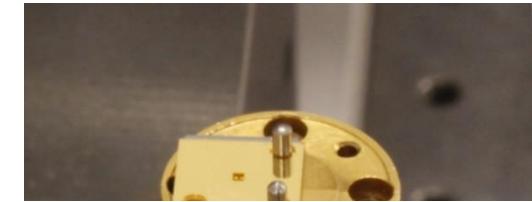
Micromachined orthogonal mode transducer (OMT) at 220-330 GHz

- First turnstile OMT above 110 GHz
- Micromachining enables microwave devices at so far unreachable frequencies!
- Size only $5 \times 5 \times 0.9 \text{ mm}^3$

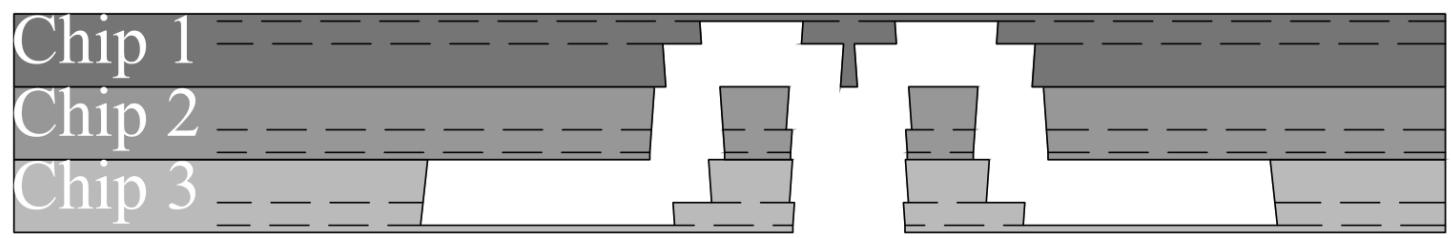
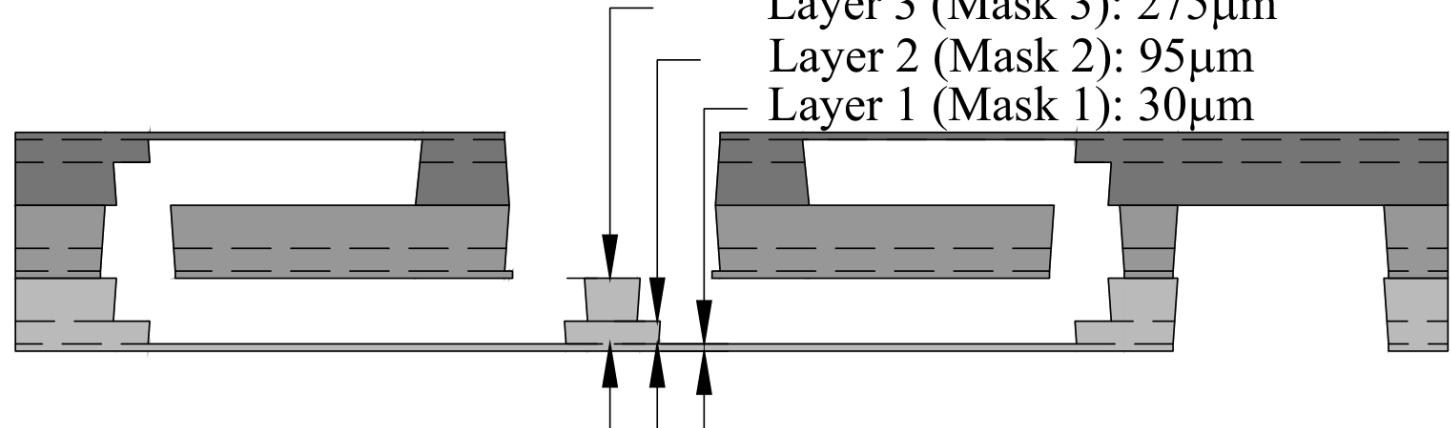


Micromachined orthogonal mode transducer (OMT) at 220-330 GHz

- First turnstile OMT above 110 GHz
- Enabled by micromachining
- 2um alignment needed



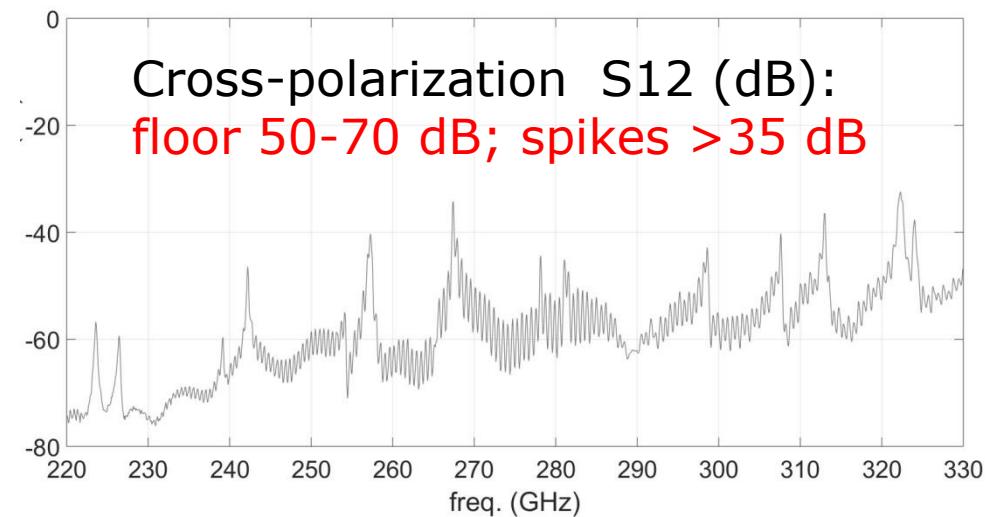
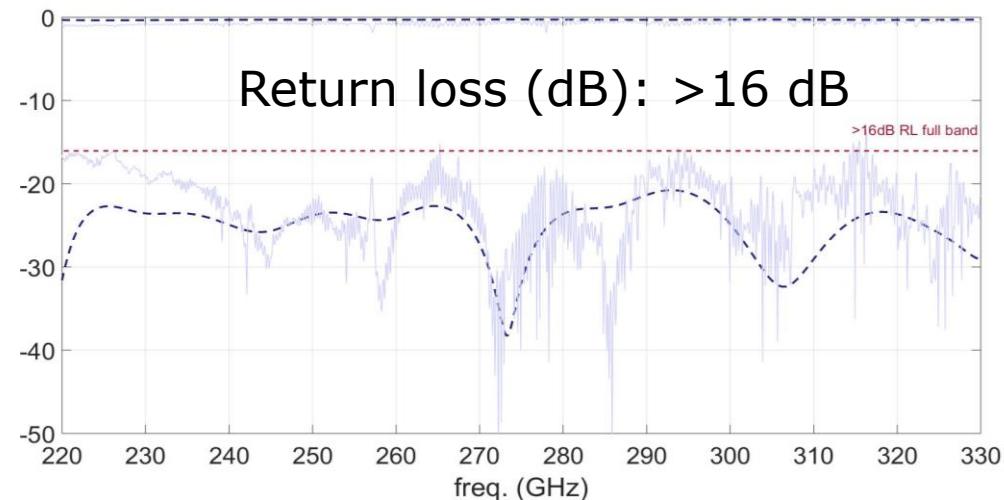
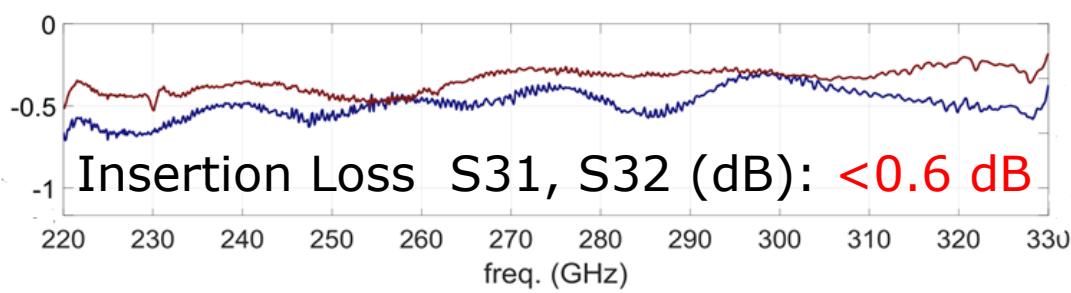
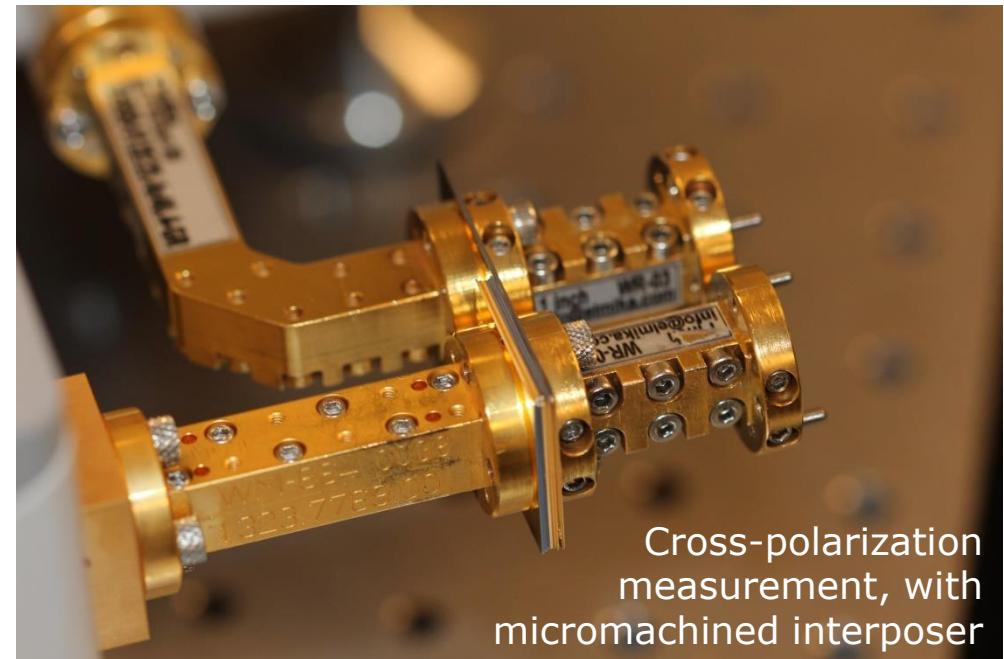
Layer 3 (Mask 3): 275 μ m
 Layer 2 (Mask 2): 95 μ m
 Layer 1 (Mask 1): 30 μ m



(b)

[IEEE IMS 2018]

Micromachined orthogonal mode transducer (OMT) at 220-330 GHz





ROYAL INSTITUTE
OF TECHNOLOGY

More complex systems: A micromachined TxRx integration platform for D-band point-to-point communication links



ROYAL INSTITUTE
OF TECHNOLOGY

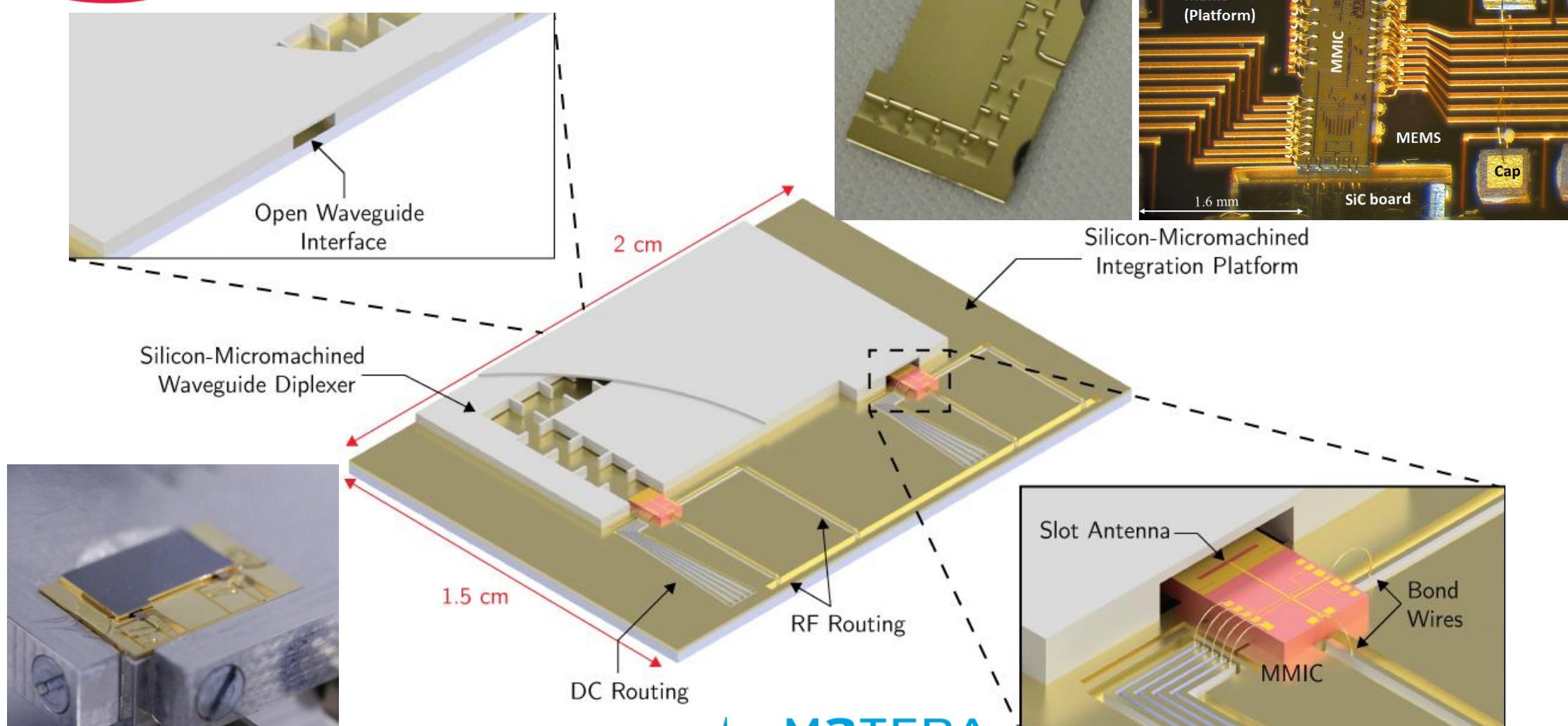


CHALMERS
UNIVERSITY OF TECHNOLOGY

Highly-integrated, micromachined D-band communication link



csem

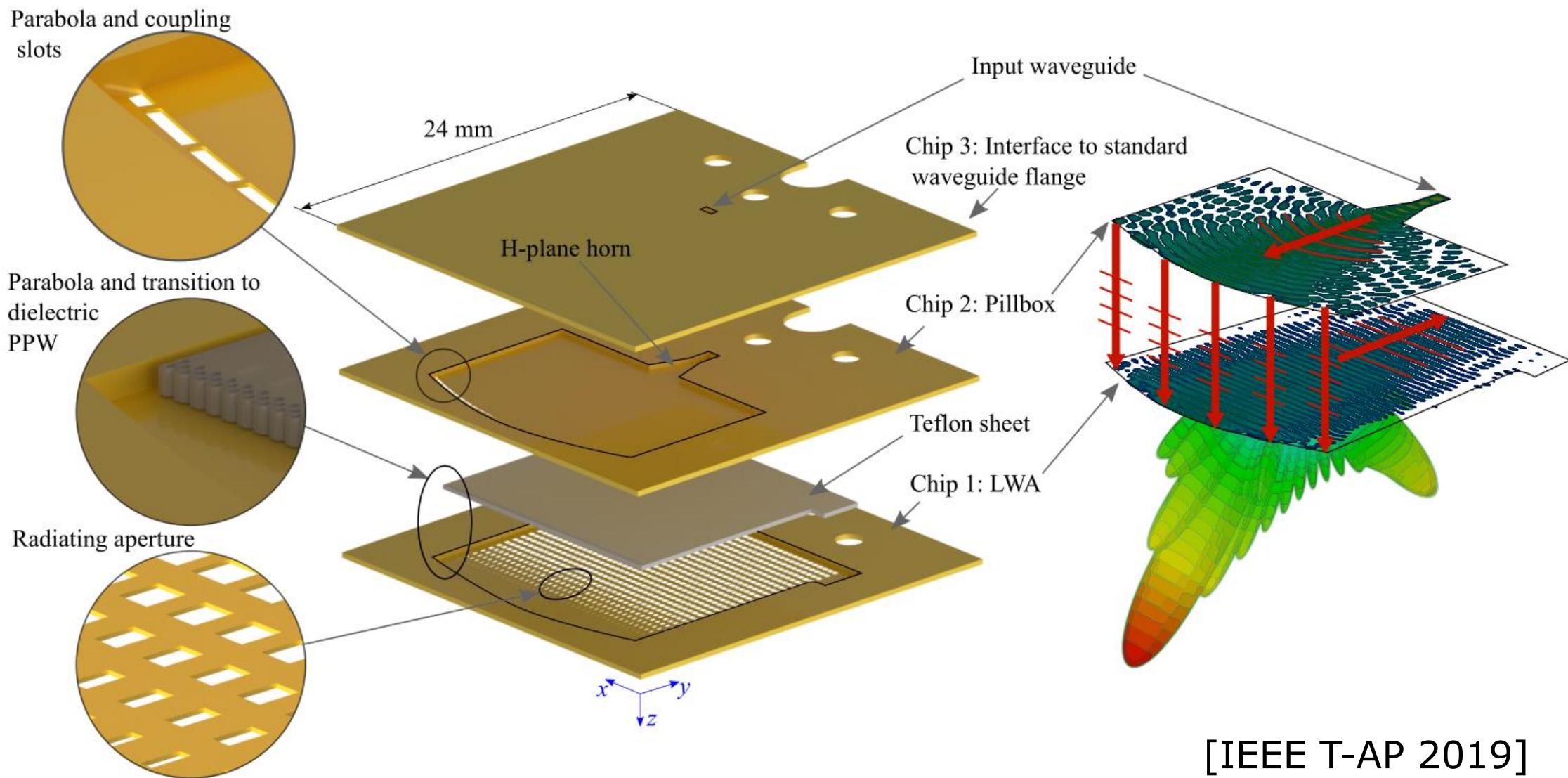




ROYAL INSTITUTE
OF TECHNOLOGY

A micromachined high-gain leaky-wave antenna for beam steering at 220-300 GHz

Micromachined “pill-box” beam-steering antenna



[IEEE T-AP 2019]

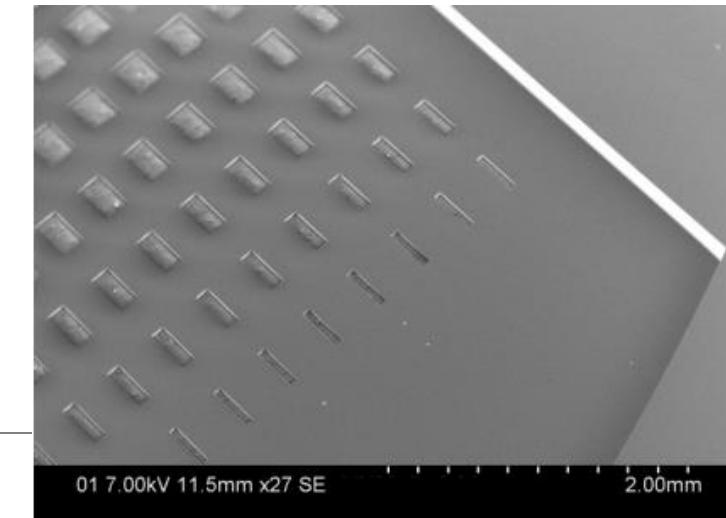
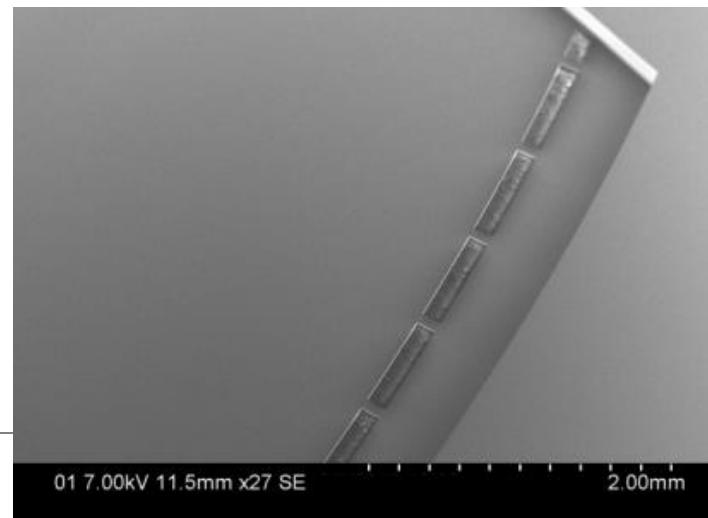
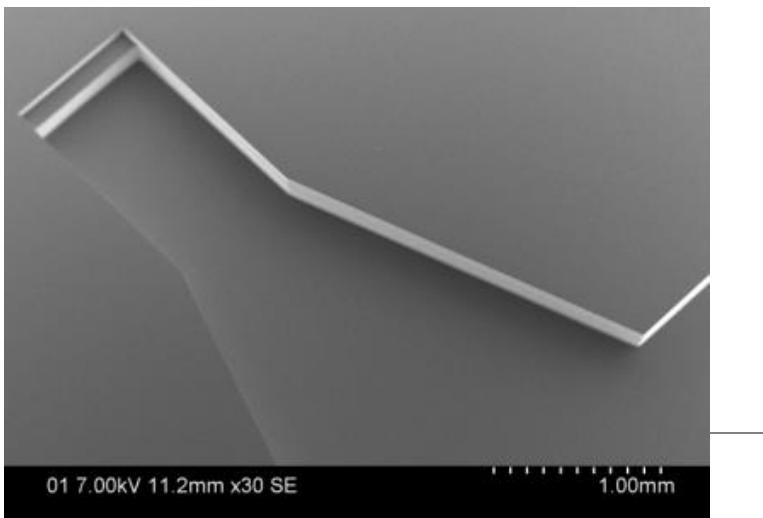
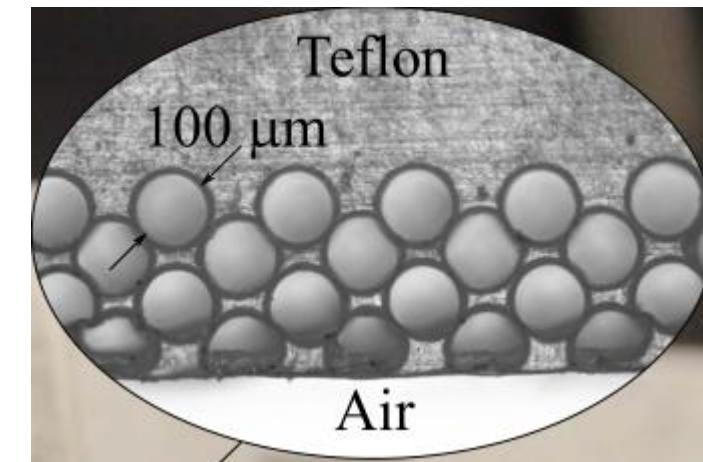
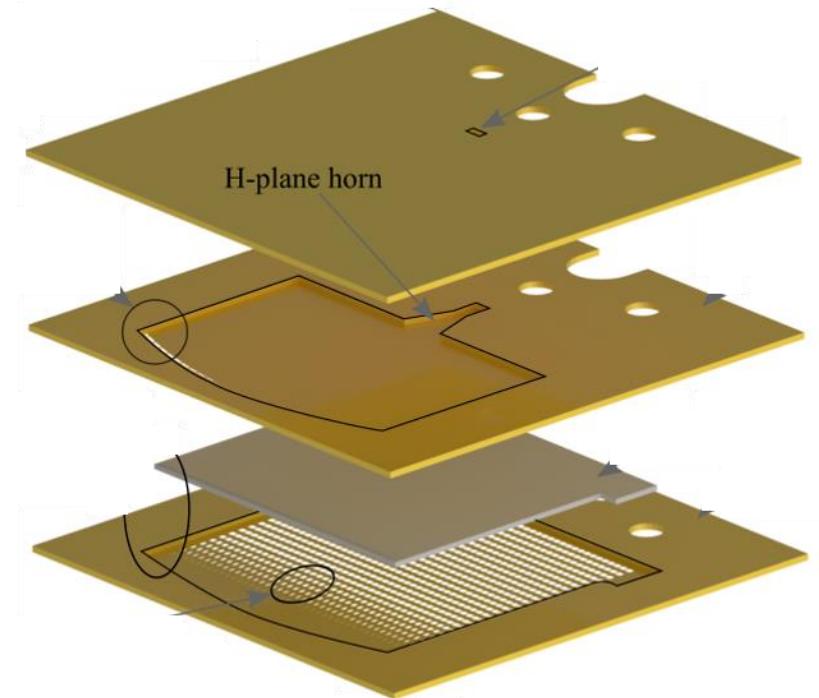


ROYAL INSTITUTE
OF TECHNOLOGY

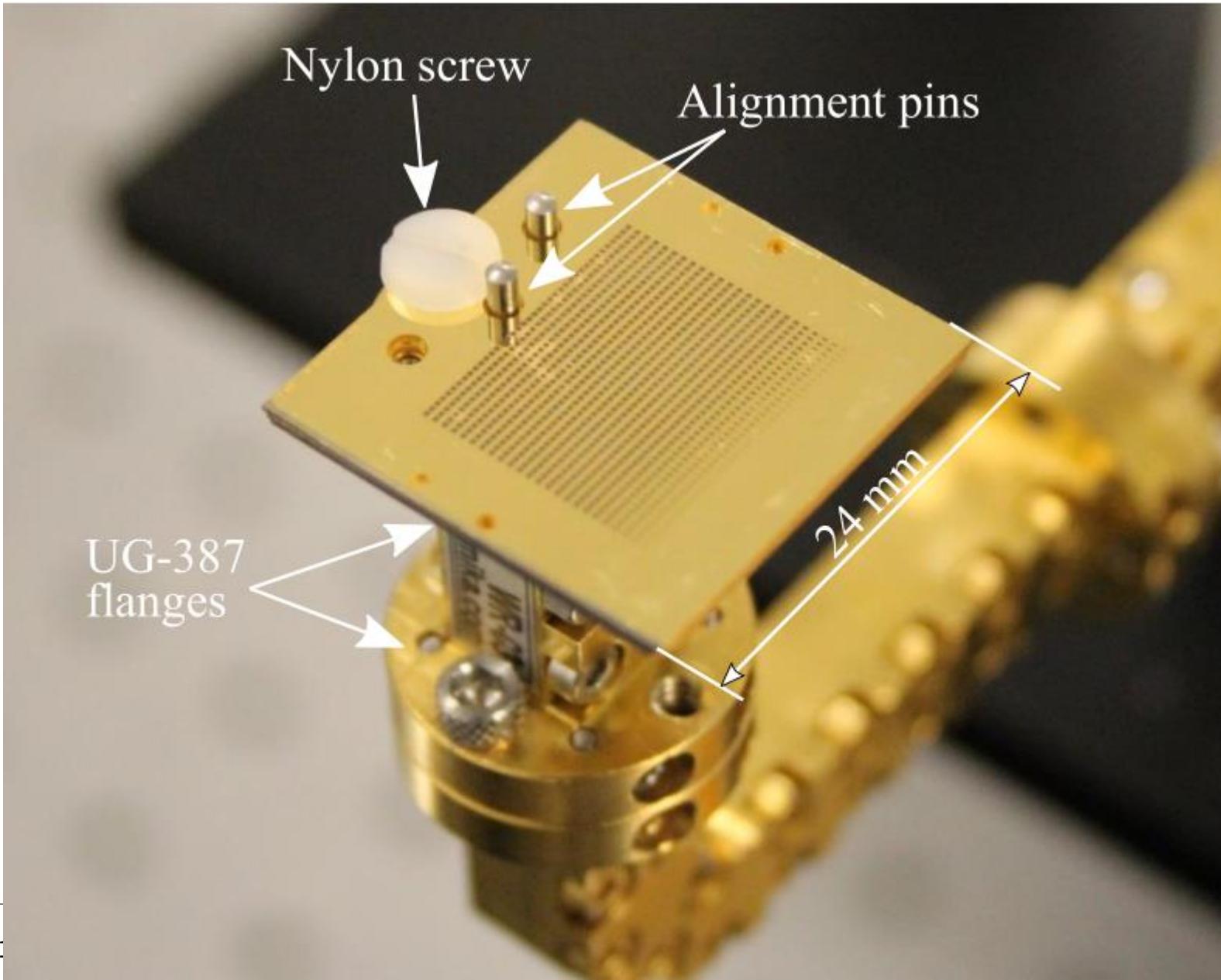
UNIVERSITÉ DE
RENNES 1

Micromachined “pill-box” Leaky-wave antenna

[IEEE T-AP 2019]

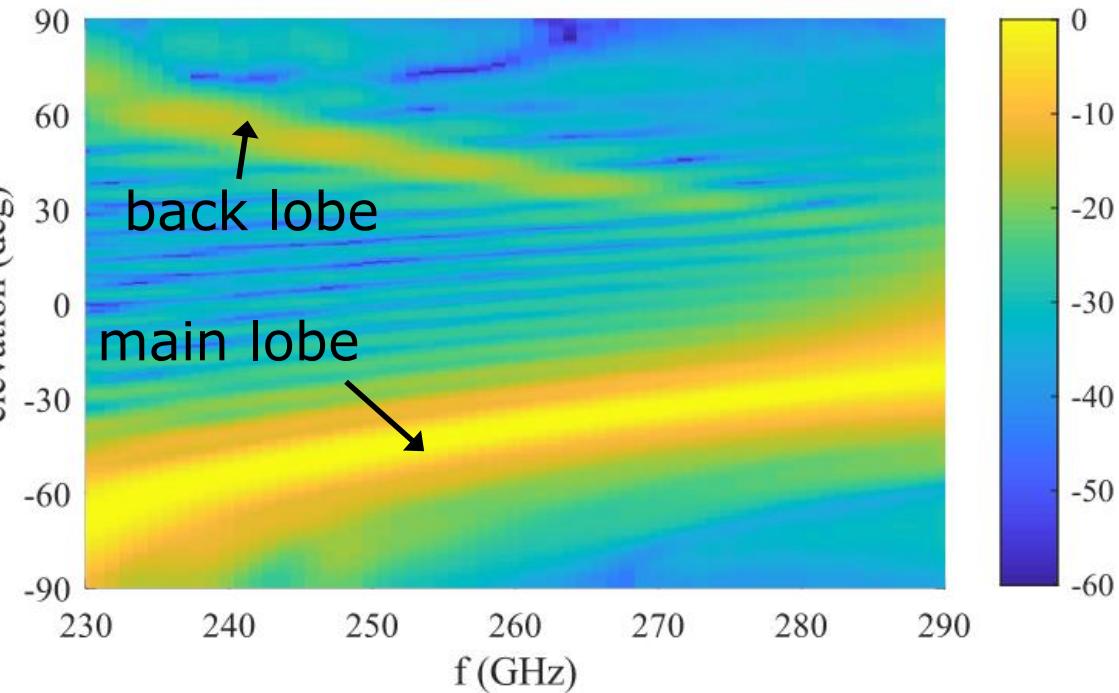
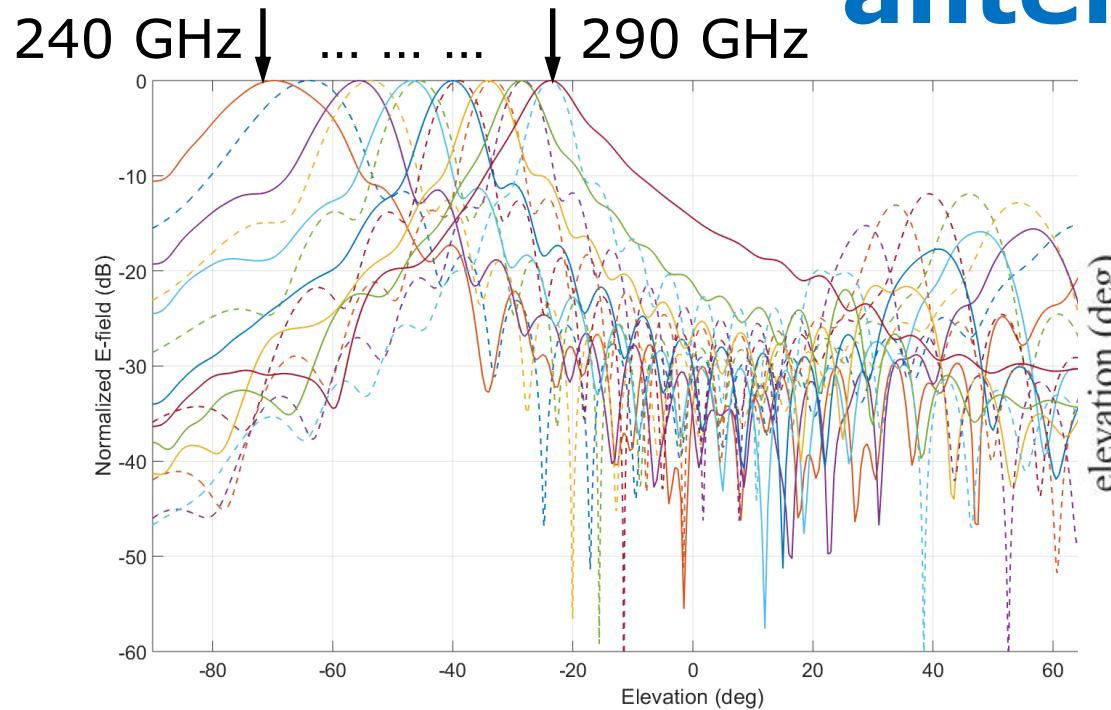


Micromachined “pill-box” beam-steering antenna



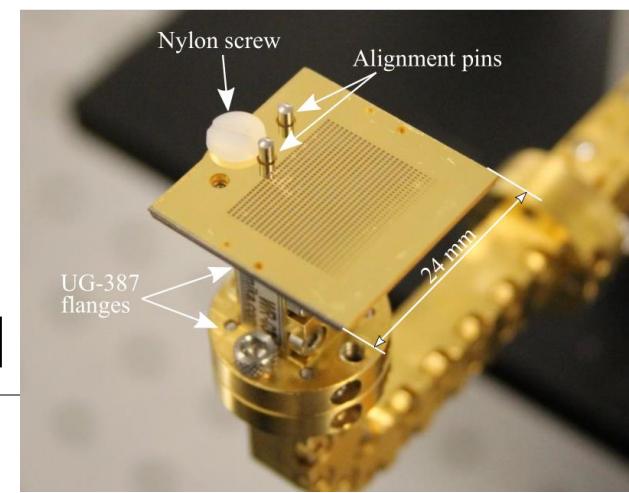
[IEEE T-AP 2019]

Micromachined high-gain beam-steering leaky-wave antenna 220-290 GHz



- size: 24x24x0.9 mm³
- 220-300 GHz frequency sweeping
=> 20°-75° scanning (55° field of view)
- measured gain: 28.5 dBi
- measured average HPBW: 7°

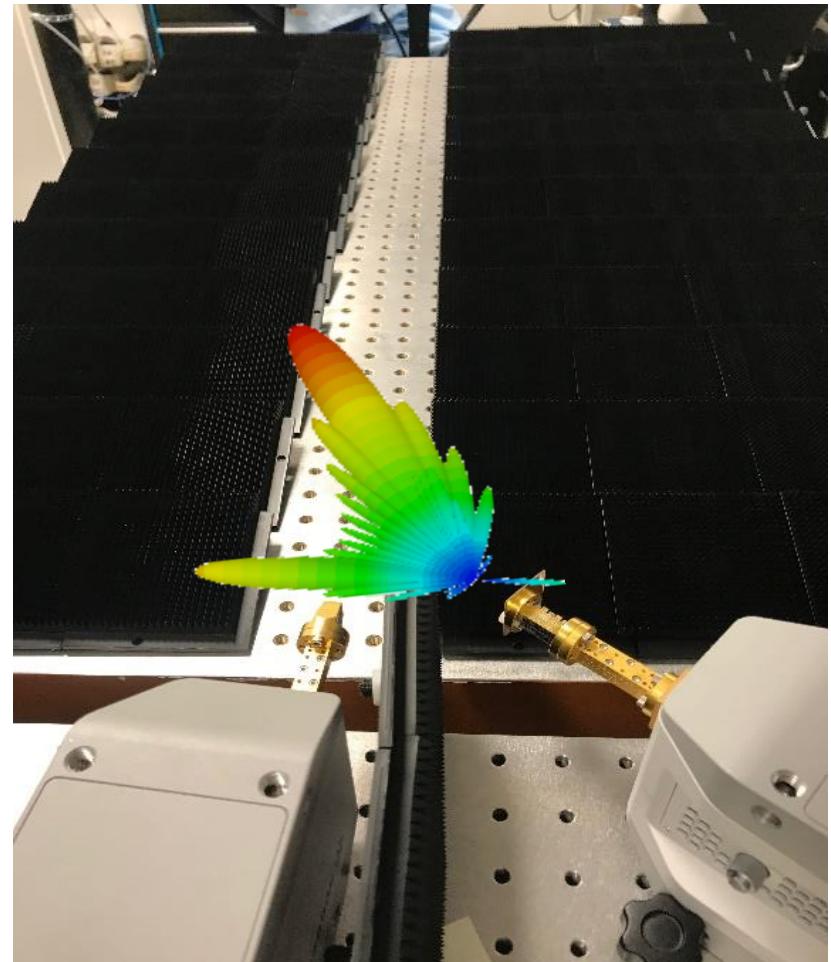
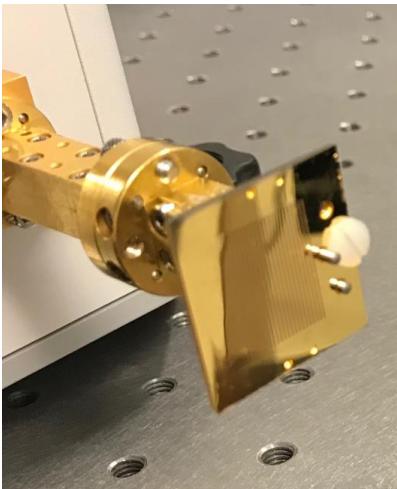
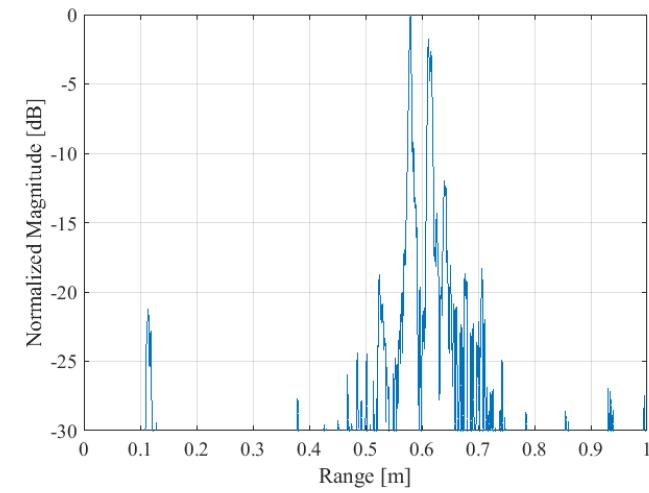
[IEEE T-AP 2019]



Radar demonstrator based on micromachined beam-steering antenna at 220-300 GHz

Micromachined radar front-end:

- $20 \times 20 \times 0.9 \text{ mm}^3$
- 220..300 GHz freq. sweep,
 $20..75^\circ$ scanning (55° FoV)
 $3.5\text{-}10^\circ$ HPBW
- <0.5 cm range resolution *at*
 $<10^\circ$ angular resolution



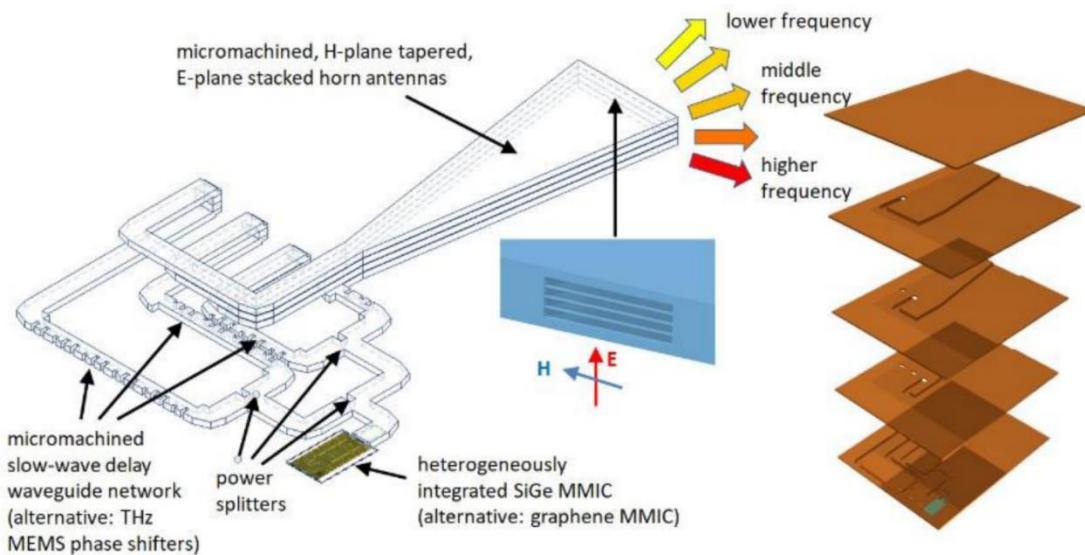
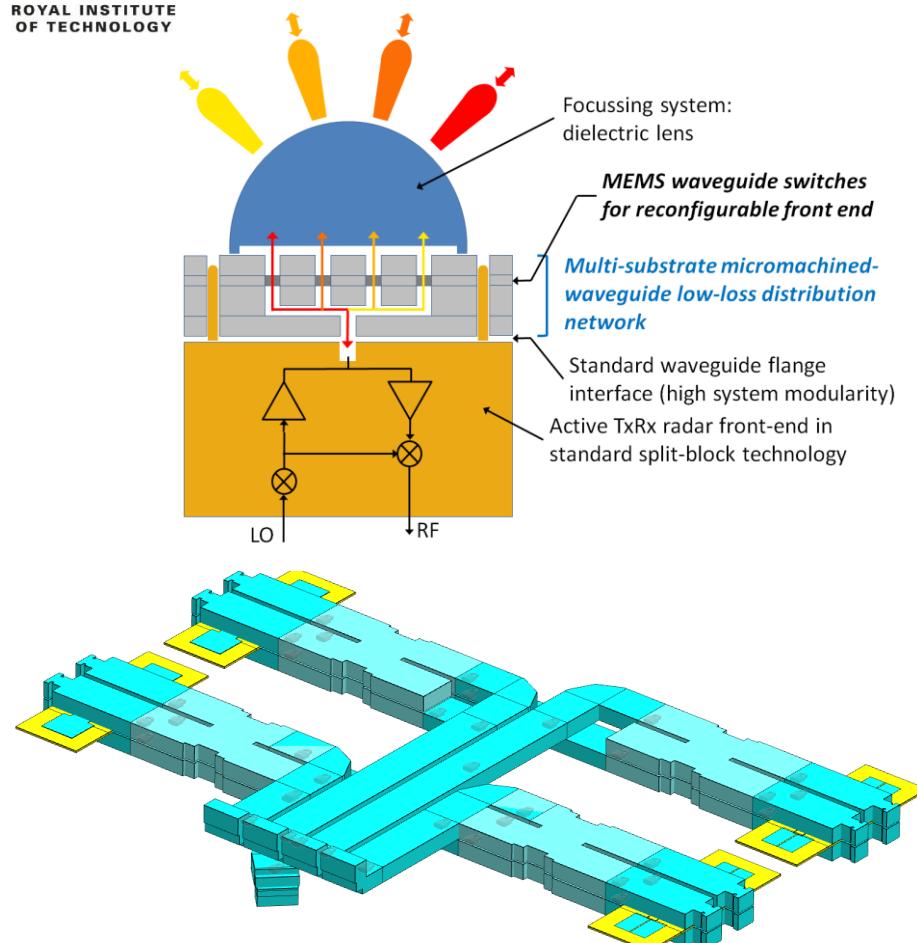
[IEEE IrMMWTHz 2019]



ROYAL INSTITUTE
OF TECHNOLOGY

Beam-switching using MEMS waveguide switches

THz MEMS for radar beam steering



238-248 GHz car radar

- micromachined beam-steering front-end
- intelligent beam-shaping

MEMS-switched 340 GHz industrial radar:

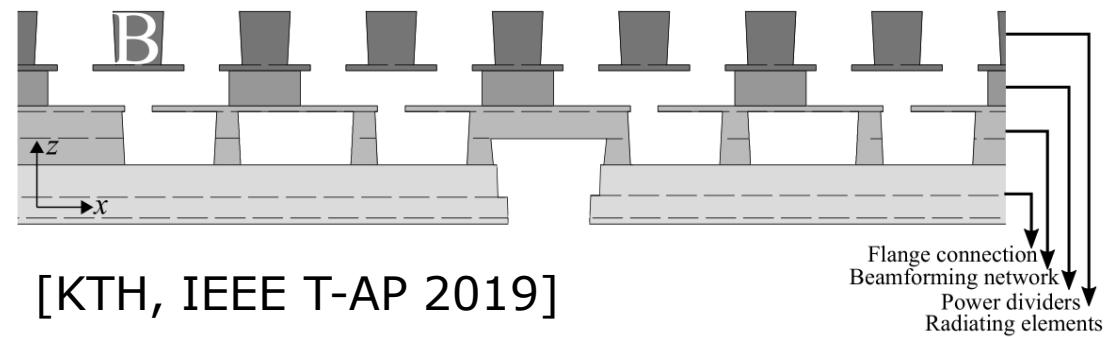
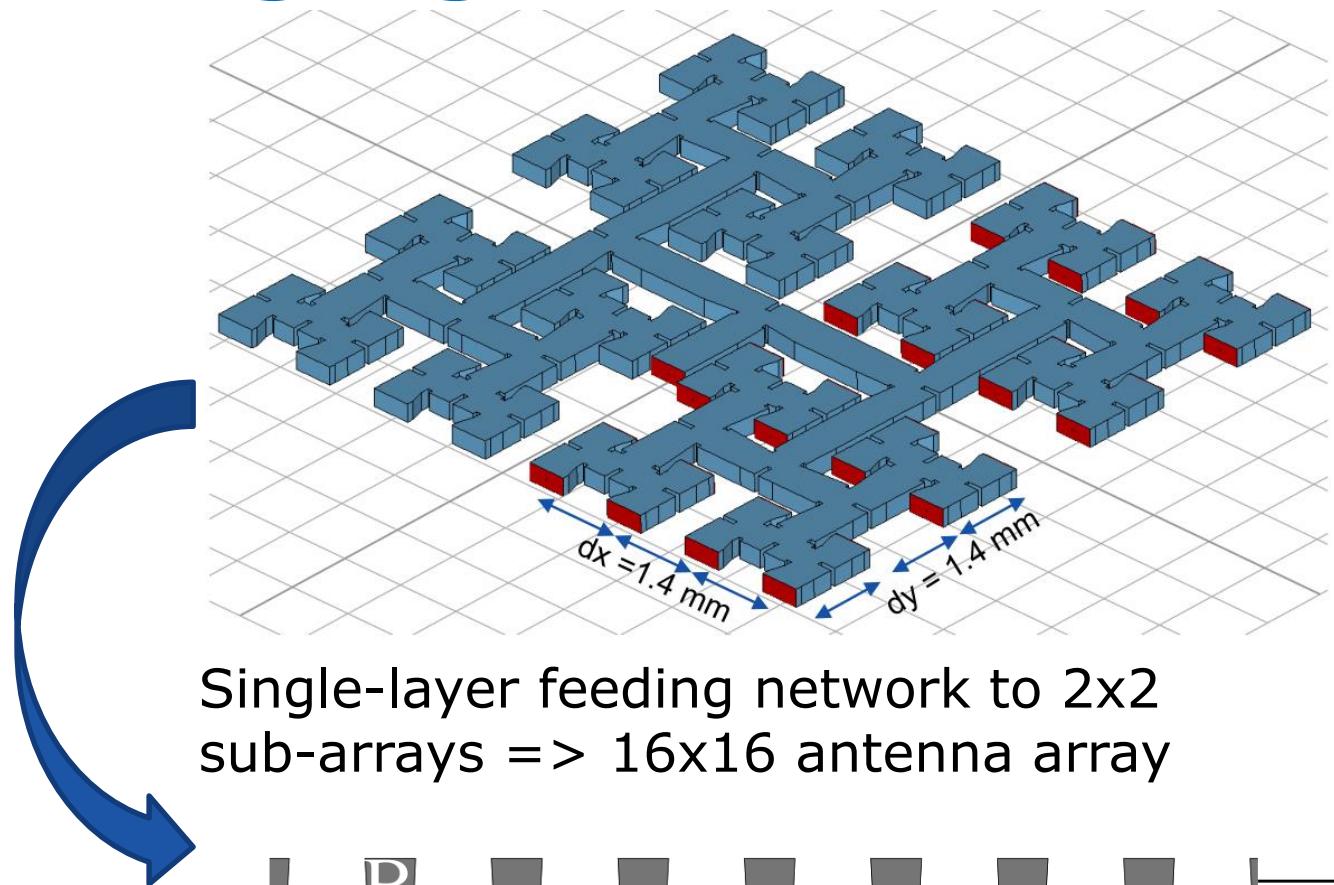
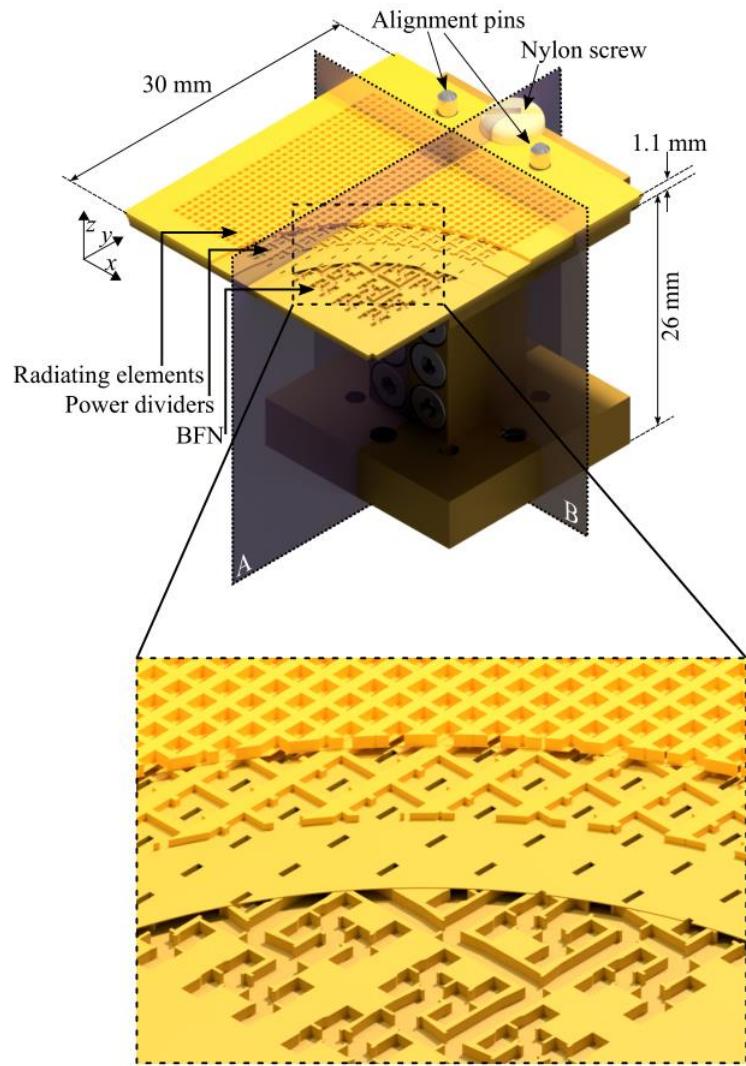
- 340 GHz, 30 GHz BW, 4x1 and 4x2 arrays
- using MEMS Waveguide switches:
 $<0.6\text{dB IL}$, $>50 \text{ dB ISO}$



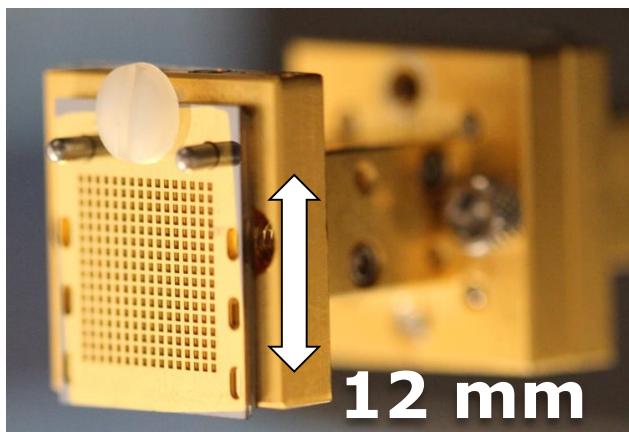
ROYAL INSTITUTE
OF TECHNOLOGY

Ultra-compact, corporate-fed, large-scale antenna arrays at 300-400 GHz

Micromachined super-compact, super high-gain antennas



Micromachined super-compact, super high-gain antennas



16x16 antenna array: 256 elements

320-400 GHz, 80 GHz BW

Directivity: 33.5 dBi

Gain: 32.8 dBi

Loss: <0.8 dB

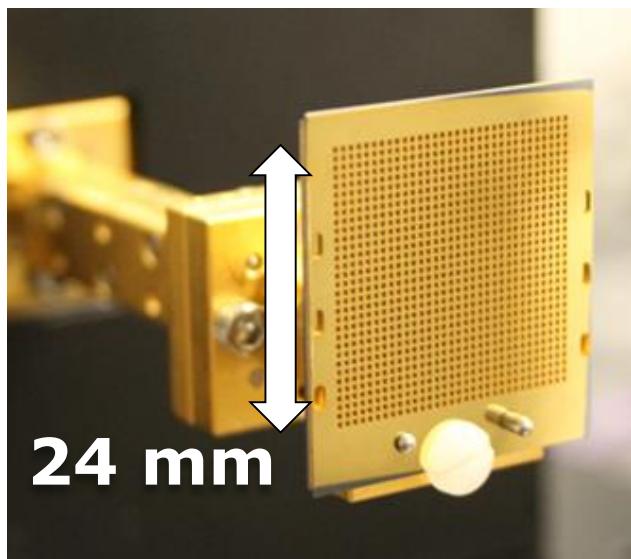
HPBW: <4.2°

Radiation efficiency: >82%

Avg. RL in band: 15 dB

Size:

12x12x1.1mm³



32x32 antenna array: 1024 elements

320-400 GHz, 80 GHz BW

Directivity: 39.7 dBi

Gain: 38.2 dBi

Loss: <1.6 dB

HPBW: <2°

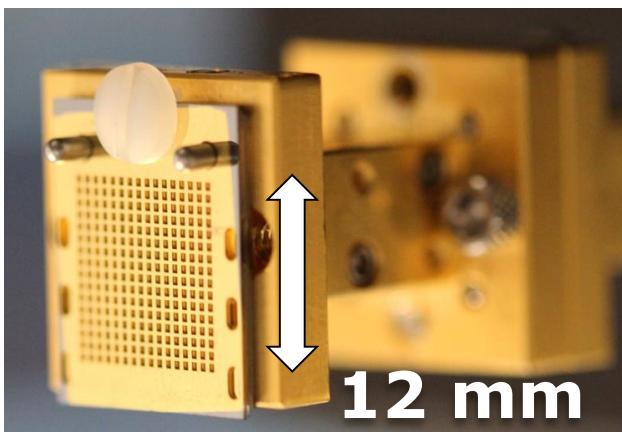
Radiation efficiency: >60%

Avg. RL in band: 15 dB

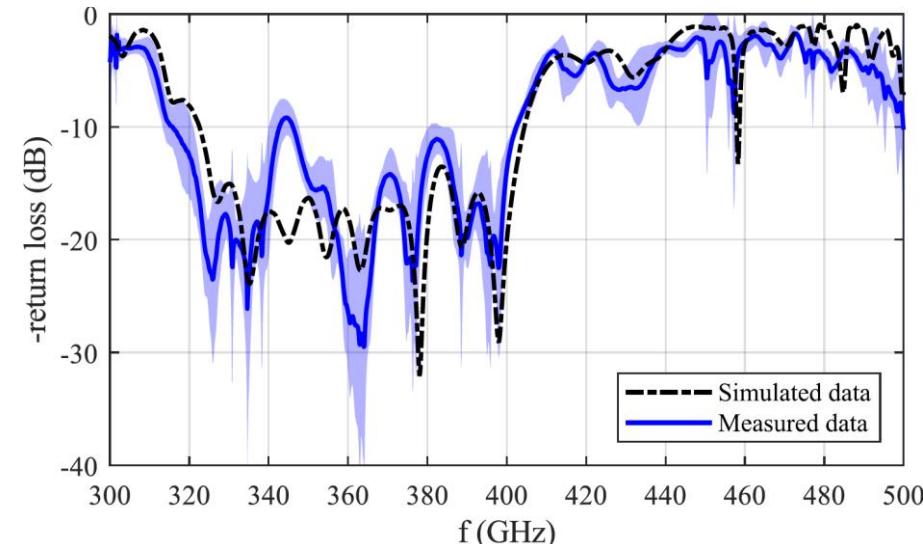
Size:

24x24x1.1mm³

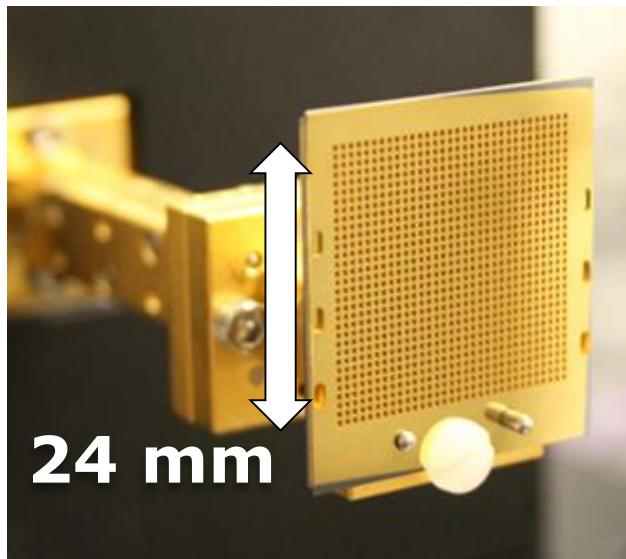
Micromachined super-compact, super high-gain antennas



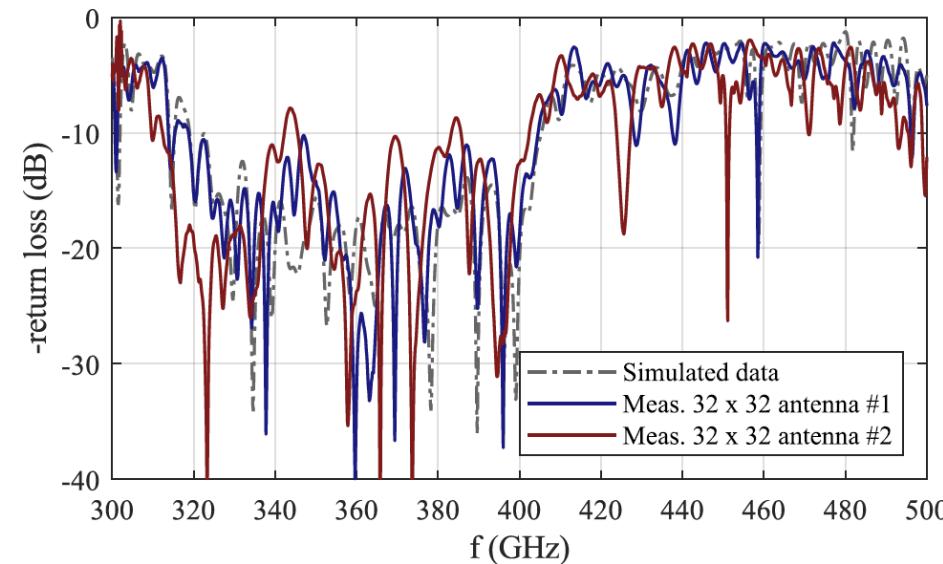
16x16 antenna array
320-400 GHz



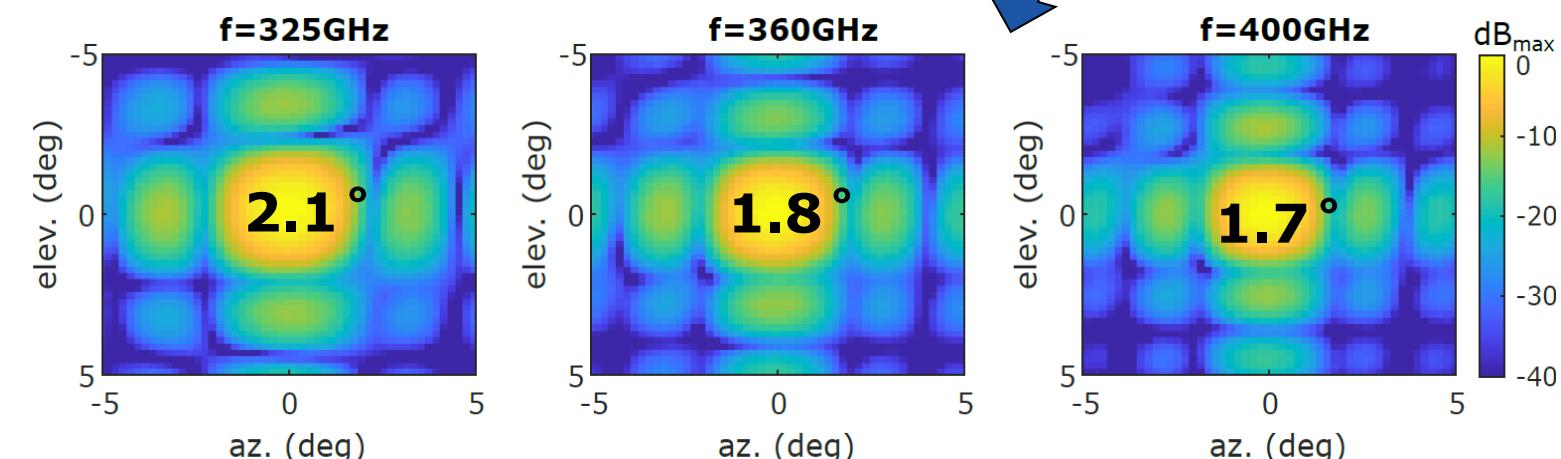
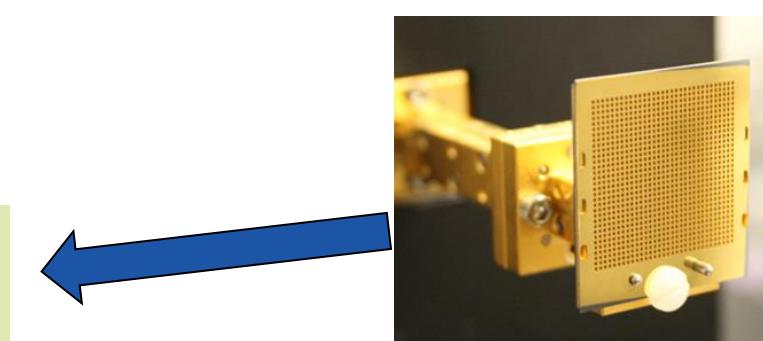
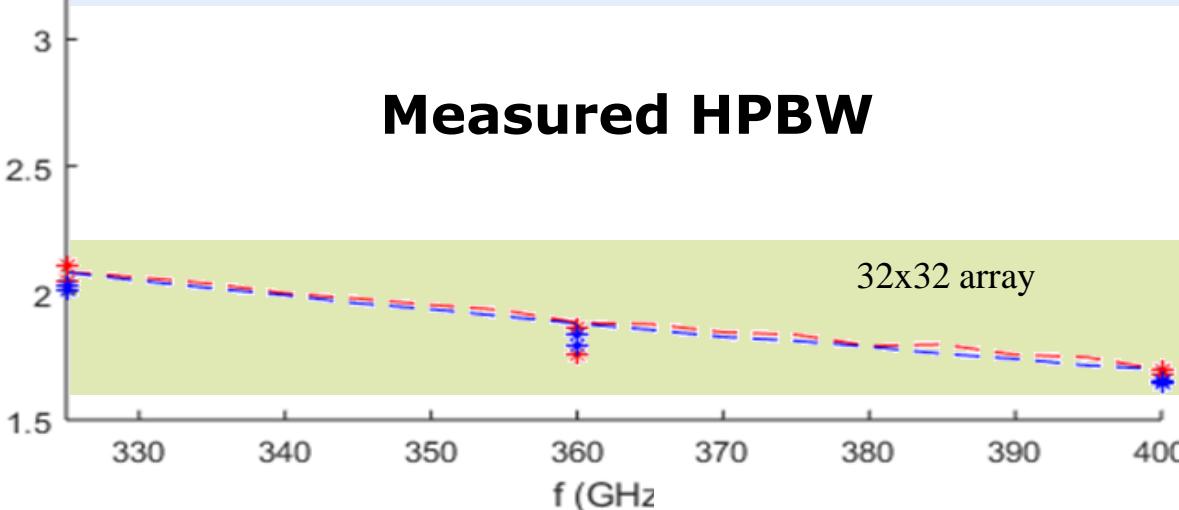
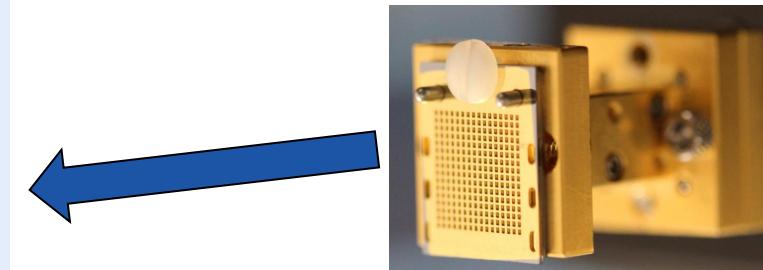
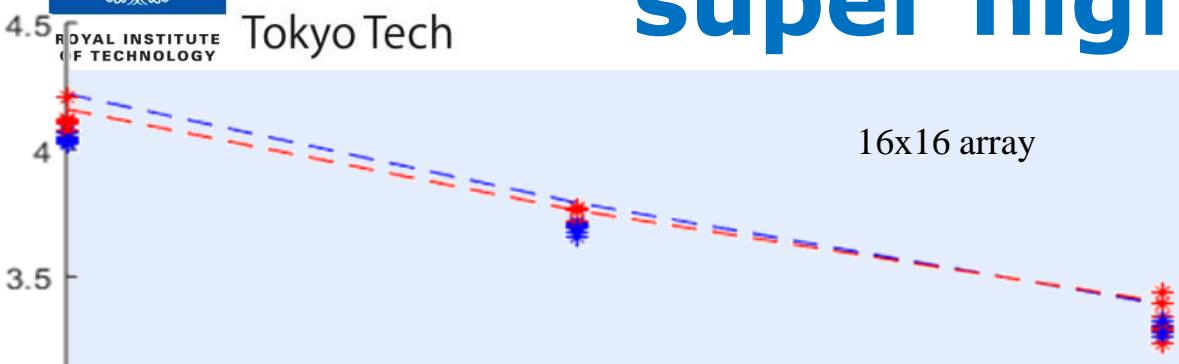
Measured RL: 80 GHz BW



32x32 antenna array
320-400 GHz



Micromachined super-compact, super high-gain antennas

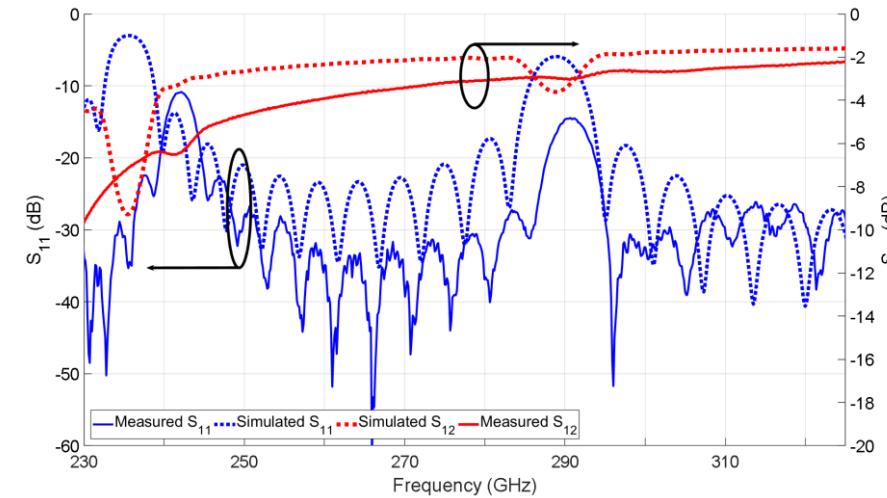
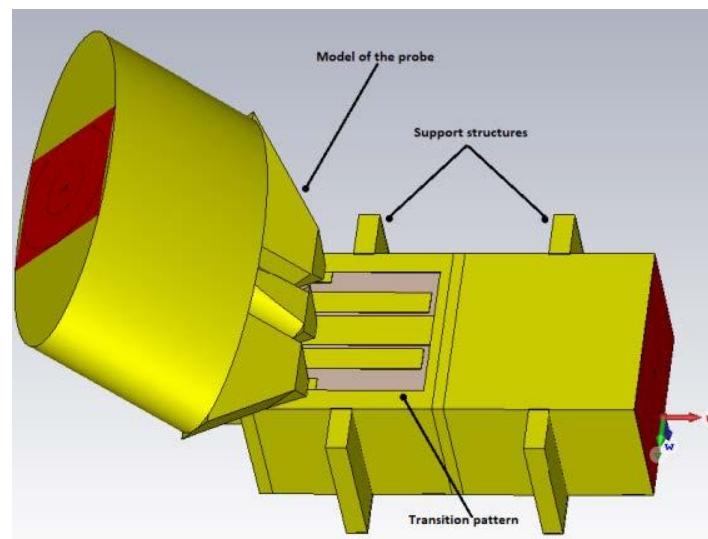
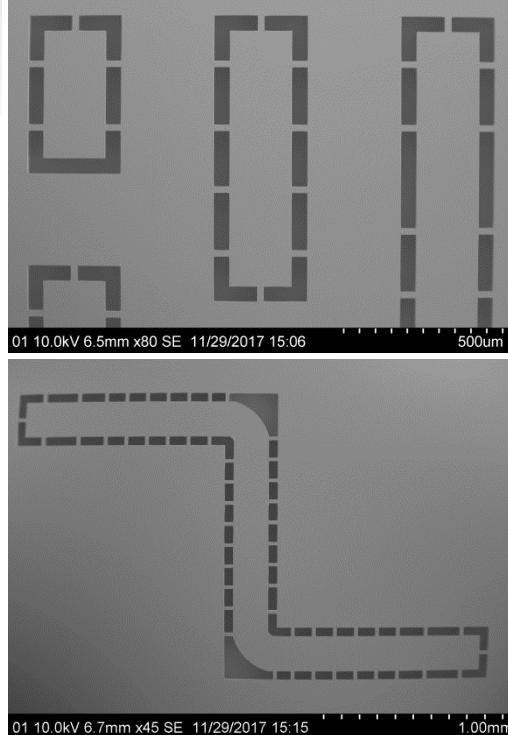
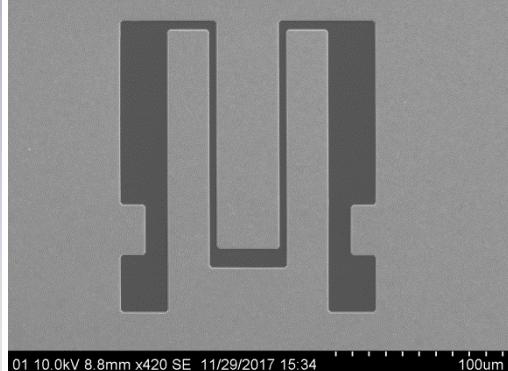
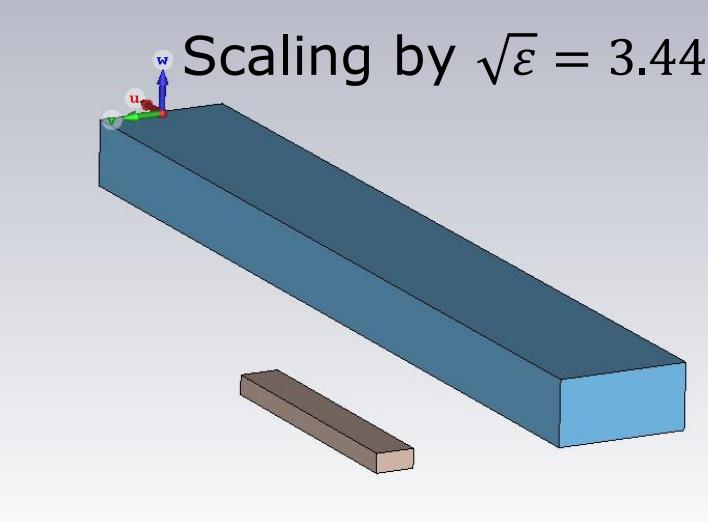




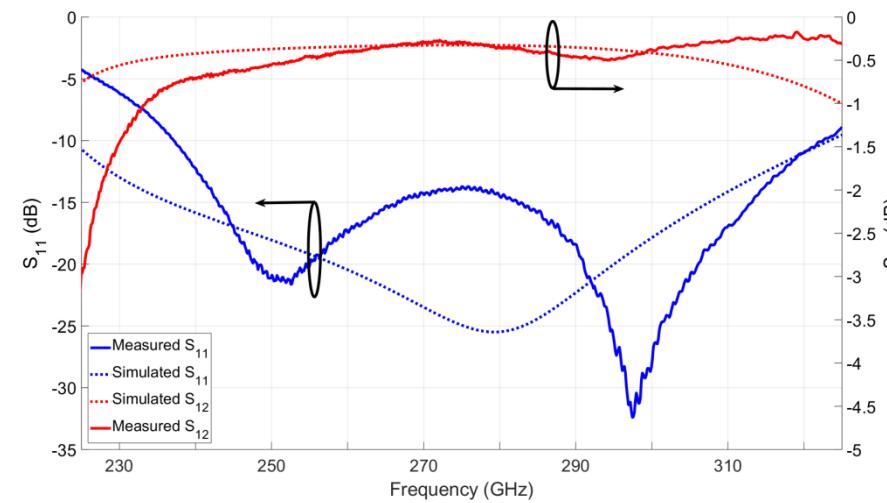
Dielectric waveguides

Silicon-core metal-WG 220-330 GHz

ROYAL INSTITUTE
OF TECHNOLOGY

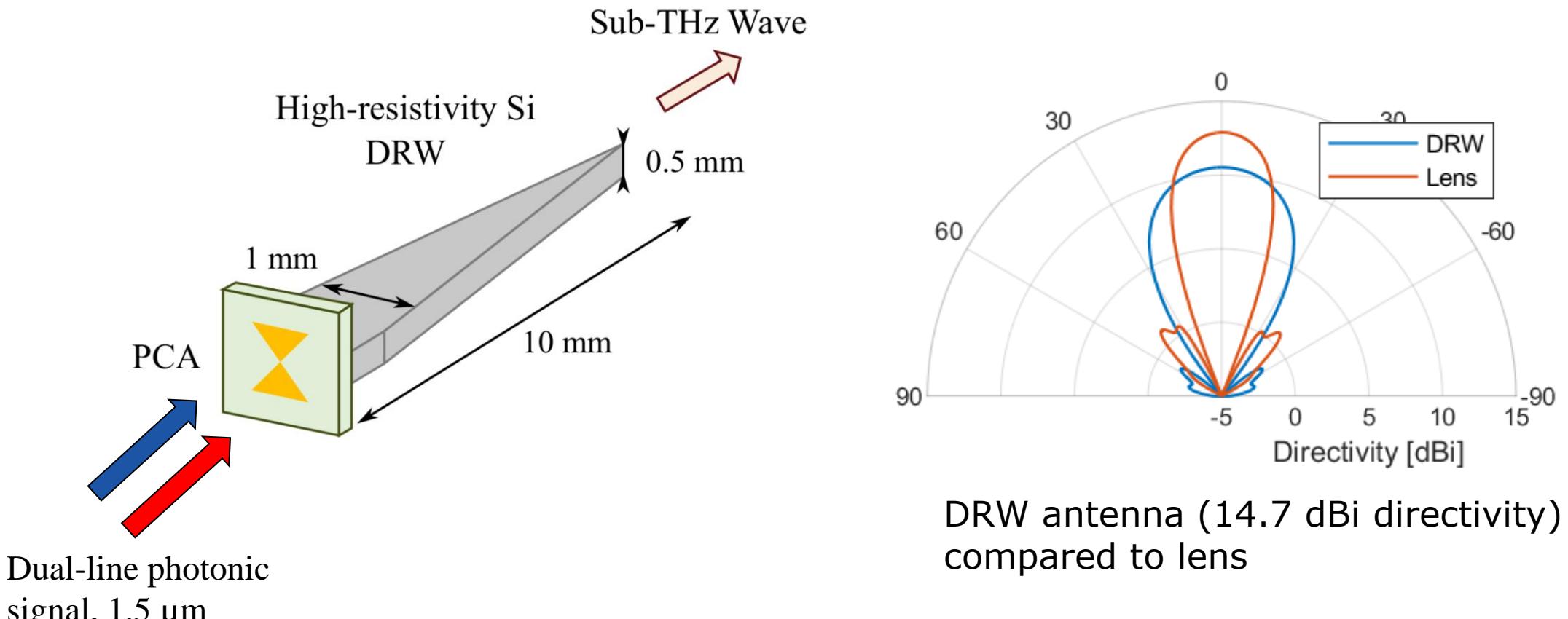


WG line $IL = 0.14 \text{ dB}/\lambda_g$



CPW transition $IL < 1 \text{ dB}$

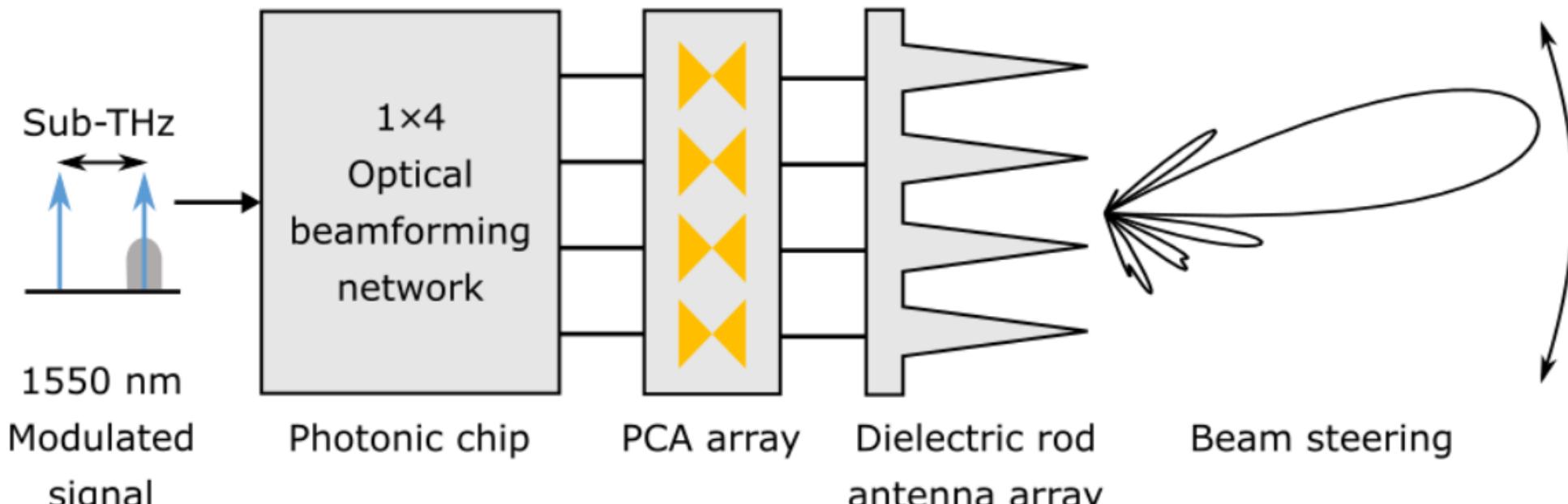
Dielectric rod waveguides (DRW) antenna with integrated photonics/microwave converter



PCA ... photoconductive antenna: bow-tie
antenna with InGaAs photodiode

[KTH, unpublished]

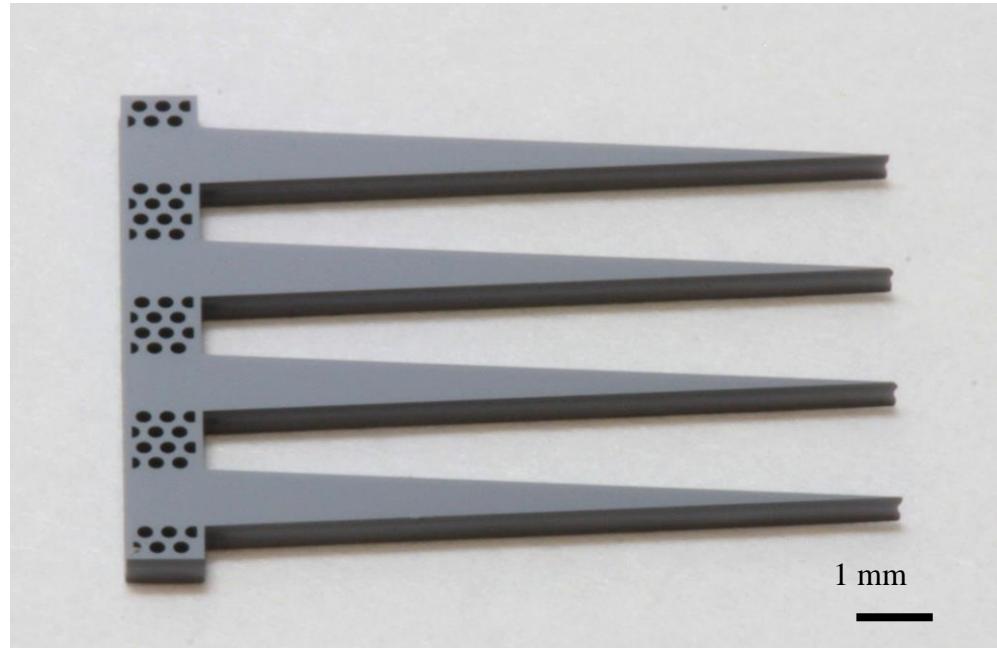
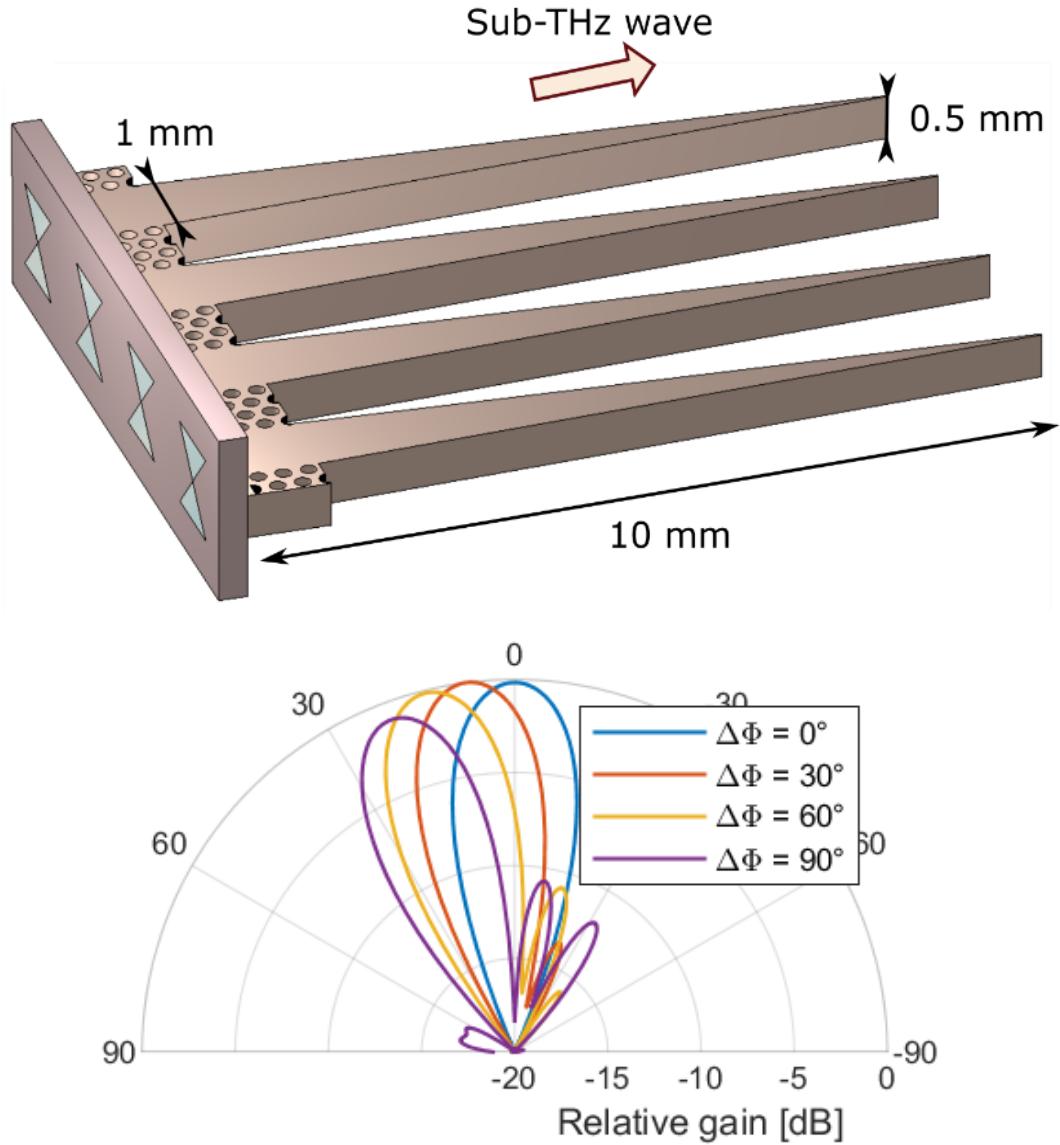
Dielectric rod waveguides (DRW) antenna arrays with integrated PCAs for beam steering



PCA ... photoconductive antenna: bow-tie antenna with InGaAs photodiode

[KTH, unpublished]

Dielectric rod waveguides (DRW) antenna arrays with integrated PCAs for beam steering



Silicon-micromachined prototype
for 85 GHz 4x1 array

[KTH, unpublished]



Conclusions

- micromachining: an enabling technology for high performance, miniaturized mmW and sub-mmW systems:
 - Very small and accurate feature size and surface roughness
 - High product uniformity, volume manufacturable
 - Integrated micromechanics => near-ideal reconfigurability
- KTH has shown many high-performance devices: filters, diplexers, phase shifters, switches, couplers, OMT

Acknowledgements:

- ERC CoG no. 616846
- Swed. Foundation for Strat. Research Synergy Grant Electronics SE13-007
- H2020 "M3TERA" GA no. 644039
- H2020 "Car2TERA" GA no. 824962
- H2020 ITN "CELT" GA no. 675683
- H2020 ITN "TESLA" GA no. 764321
- KAW Foundation
- VINNOVA Smartare Elektroniksystem



joachimo@kth.se